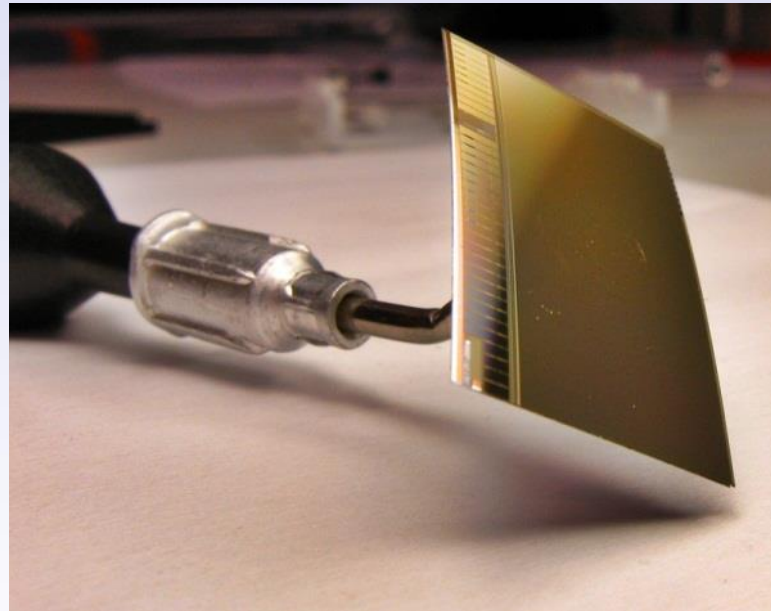


CMOS Monolithic Active Pixel Sensors

A tool to measure open charm particles

M. Deveaux

Goethe-Universität
Frankfurt/M



Sherlock Holmes and Mystery of the Soup

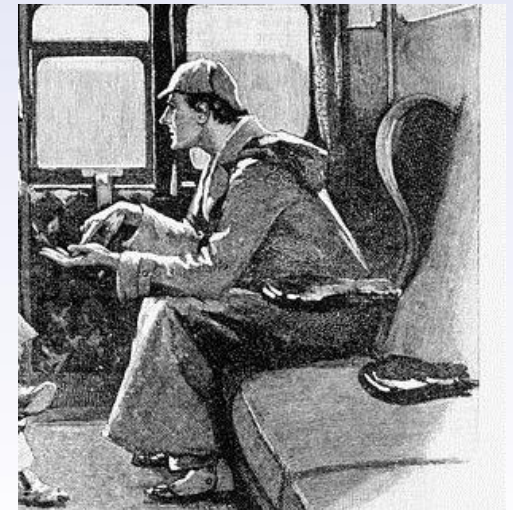
or

How to build a webcam based carrot detector

M. Deveaux

Goethe-Universität

Frankfurt/M



A Question to Sherlock Holmes



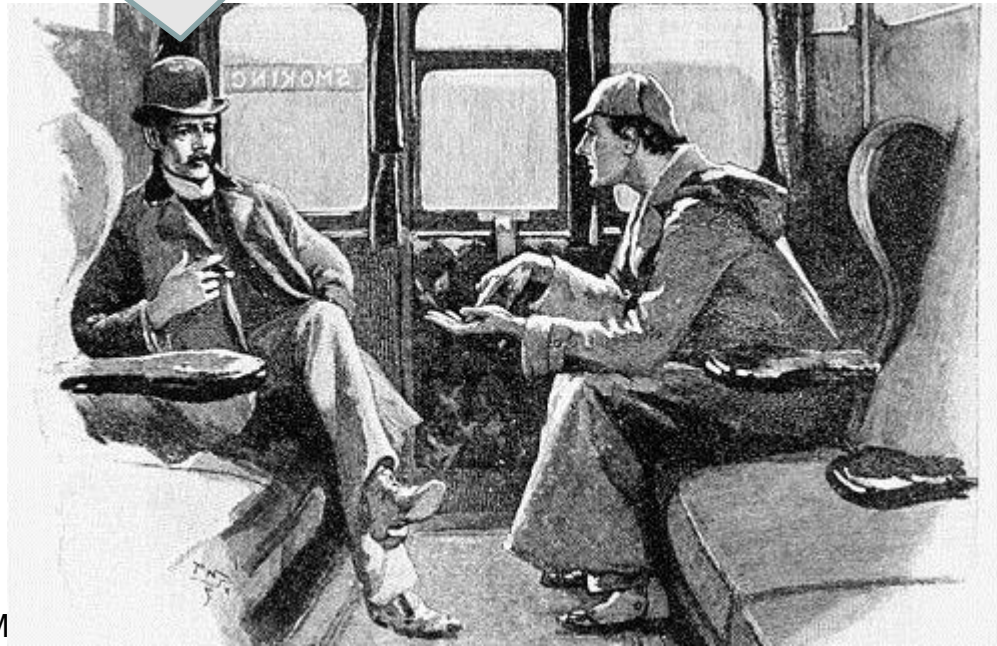
Prof. Dr. Johanna Wanka, Federal Minister of Research, Germany



The soup



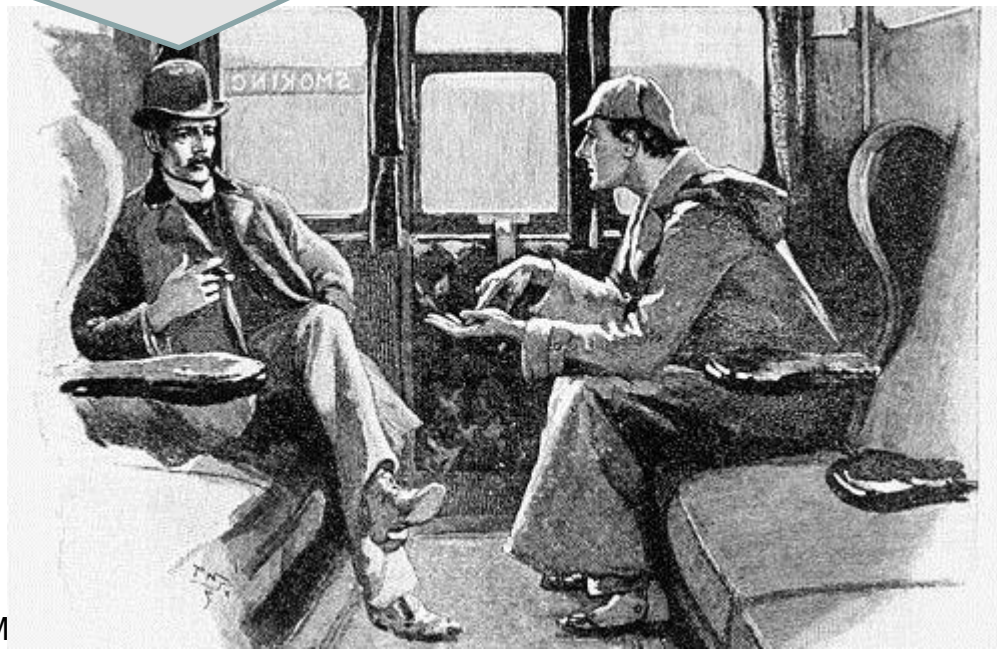
The cook



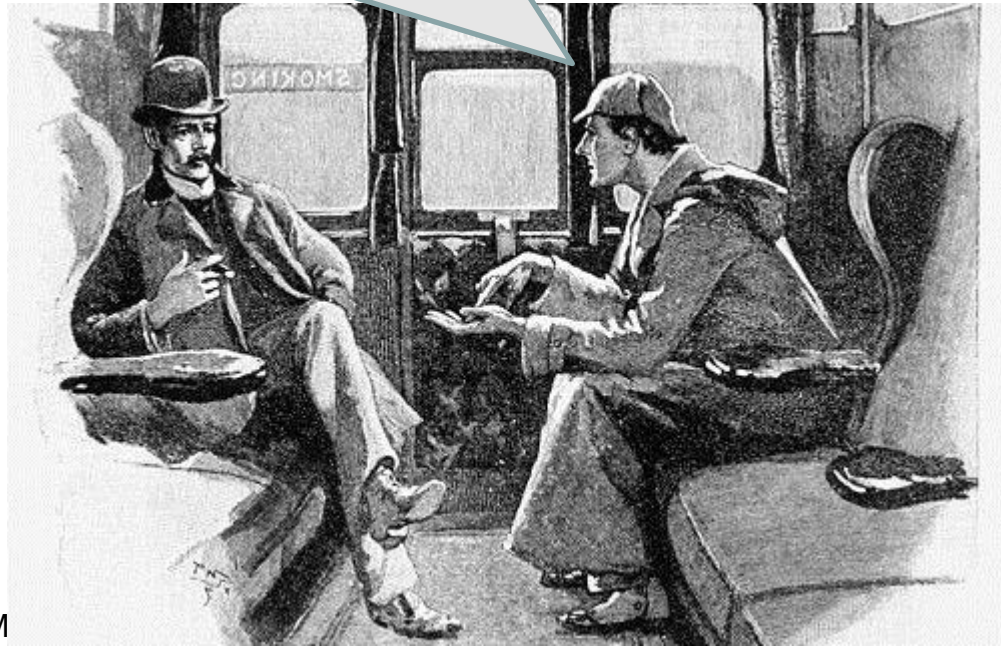
Sherlock Holmes Quest



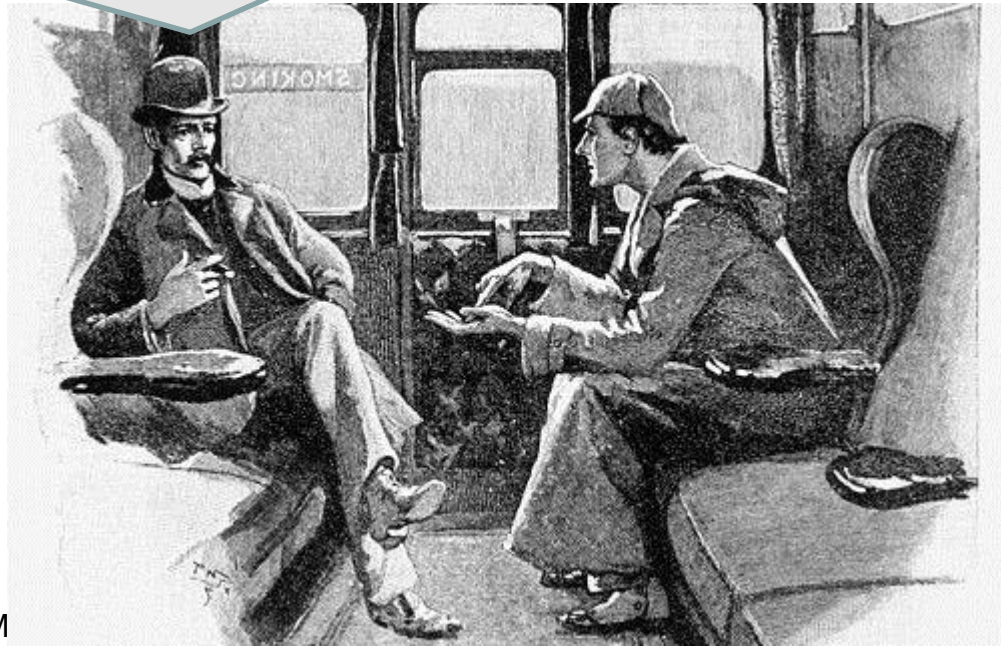
How can one check that the soup has cooked?



Sherlock Holmes Quest



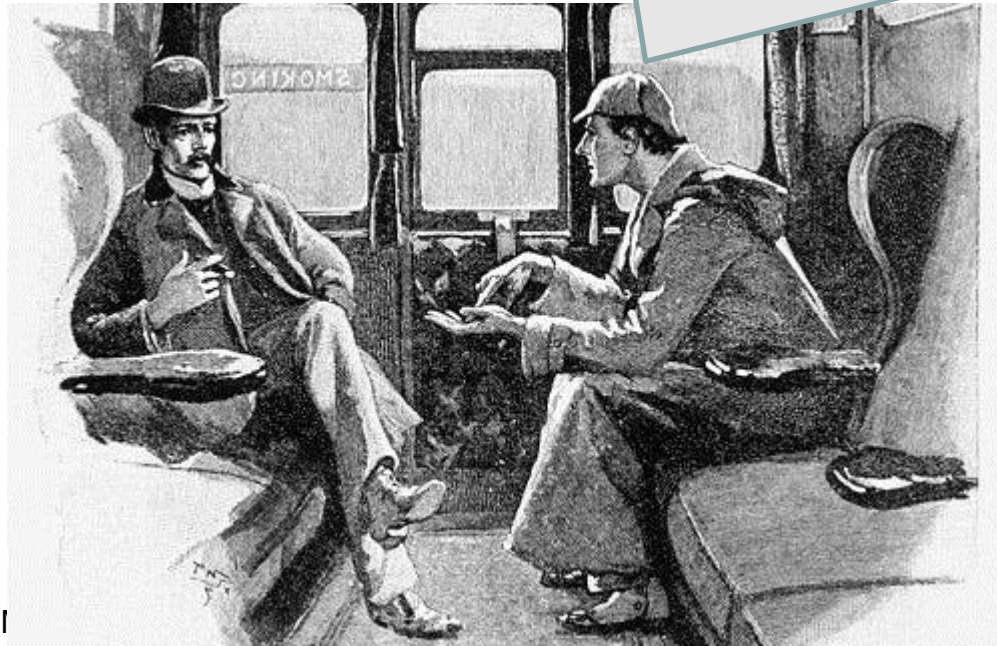
Sherlock Holmes Quest



Sherlock Holmes Quest



=



Sherlock Holmes Quest



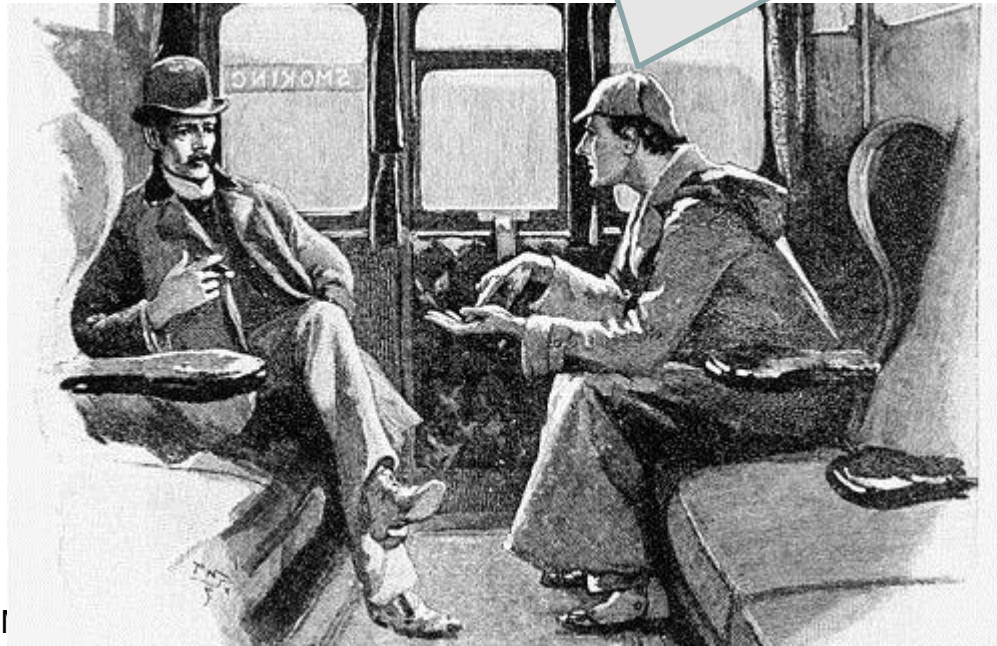
Dissolves fast



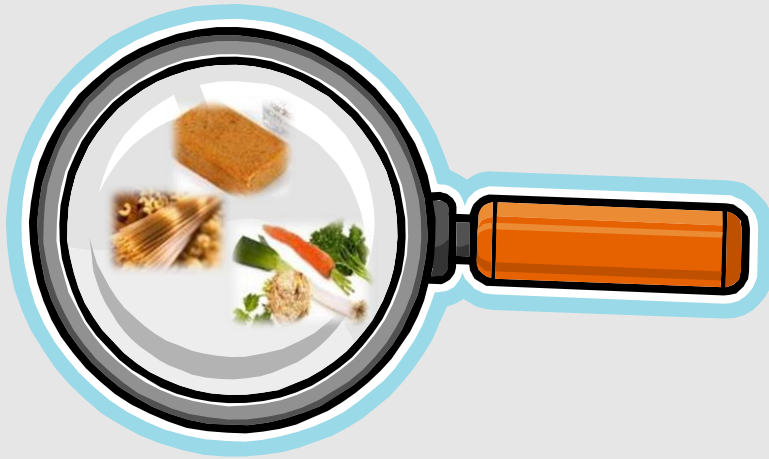
Gets quickly soft if cooked



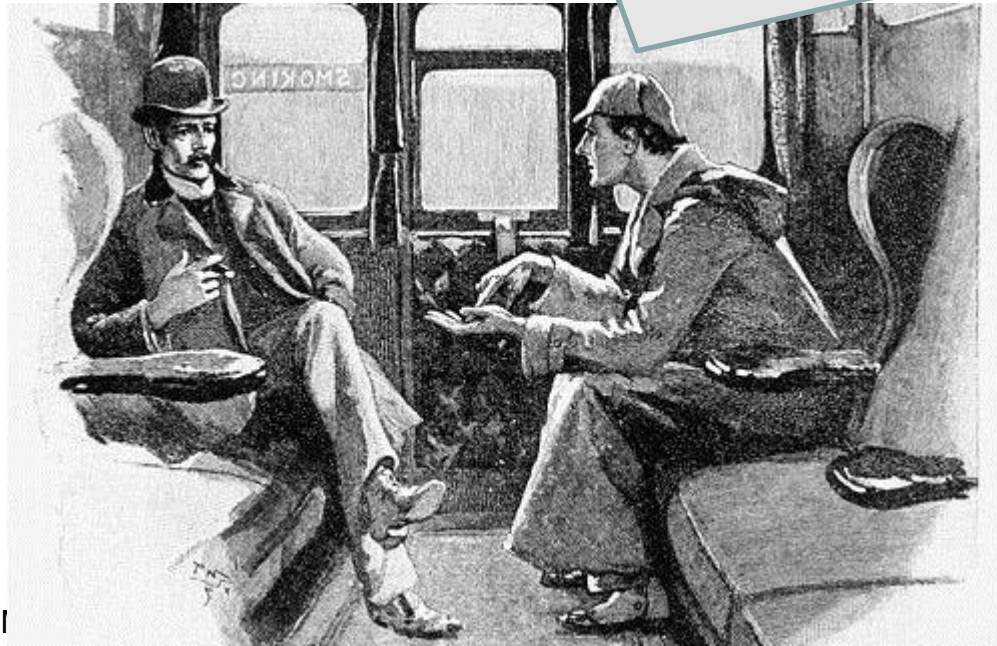
Gets slowly soft if cooked



Sherlock Holmes Quest



Lets test ingredients,
which keep
information on the
cooking process.



Sherlock Holmes Quest



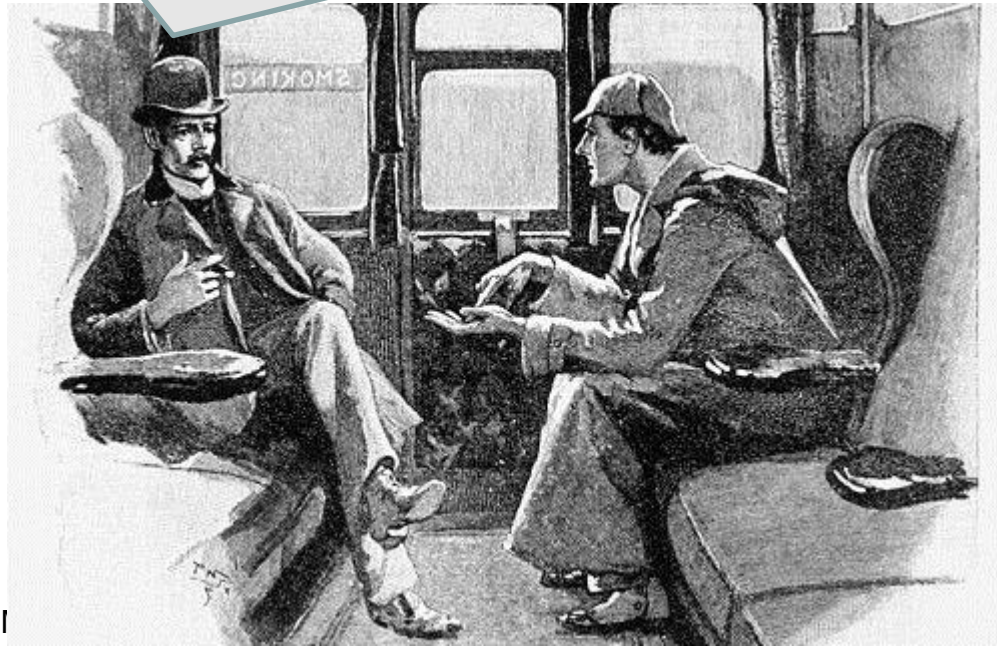
Dissolves also at room temperature



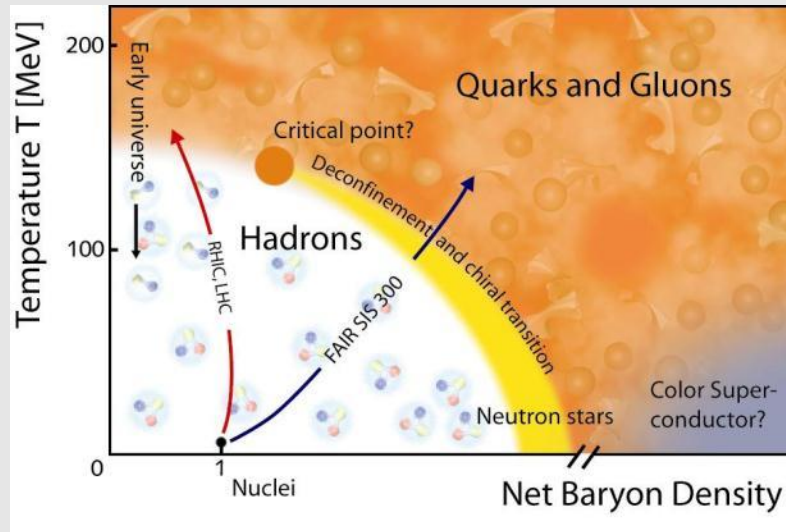
Keeps softening after cooking



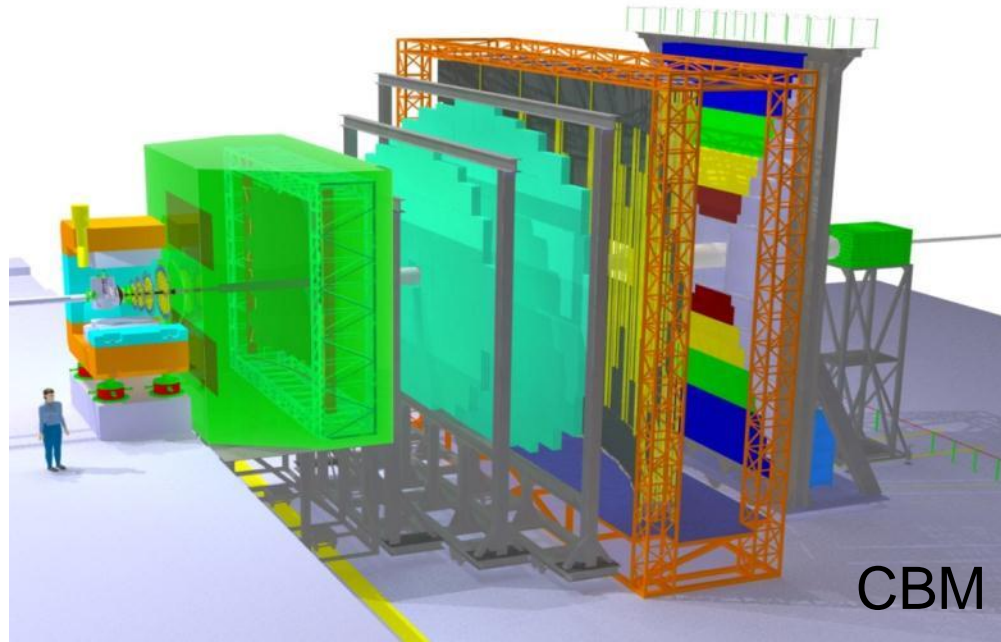
Reacts slowly, might overlook cooking



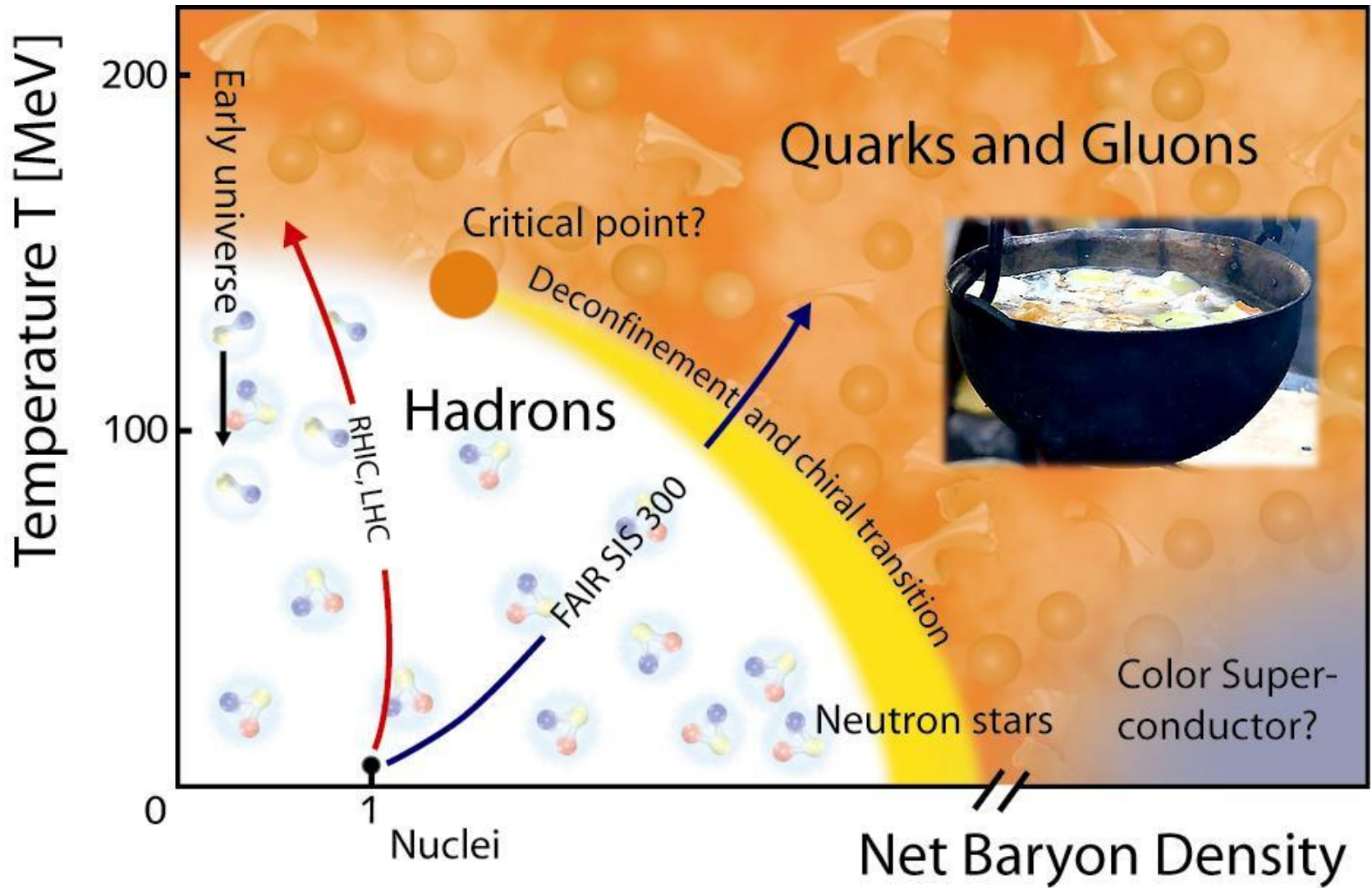
The Quest of modern heavy ion experiments



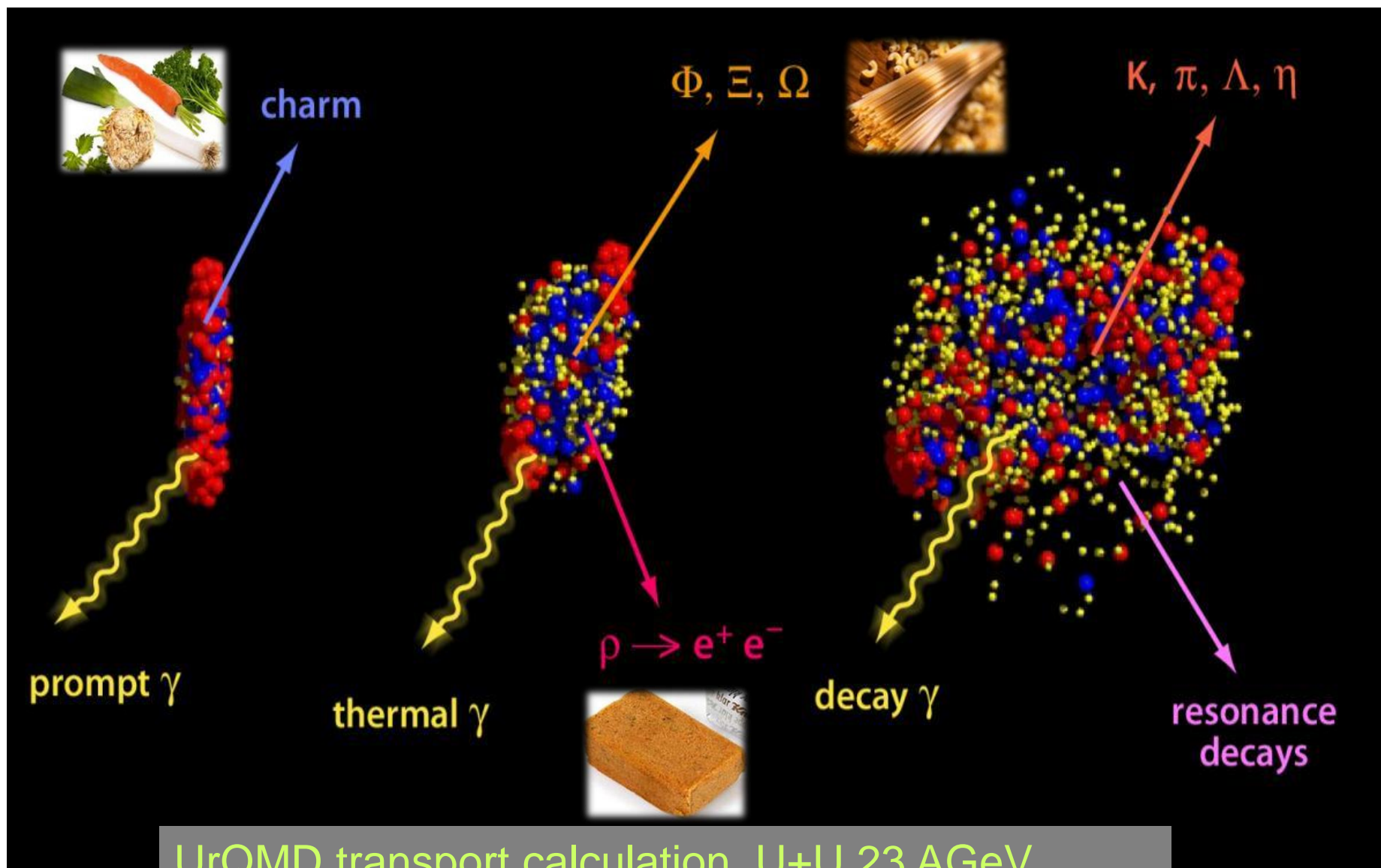
We will have to test as many ingredients as possible to obtain a conclusive answer.



What means soup: Hadronic Matter



What means carrot: Observables



UrQMD transport calculation U+U 23 AGeV

My topic today

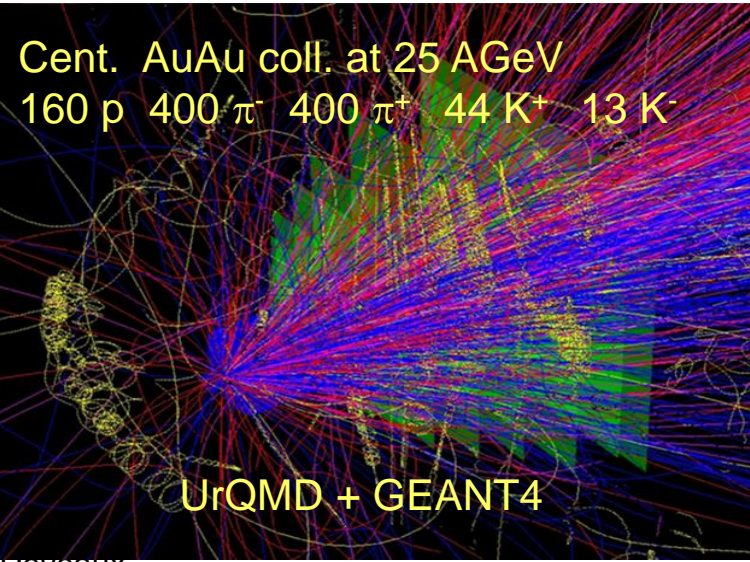


How can

← this technology help to...

find this...

in this!

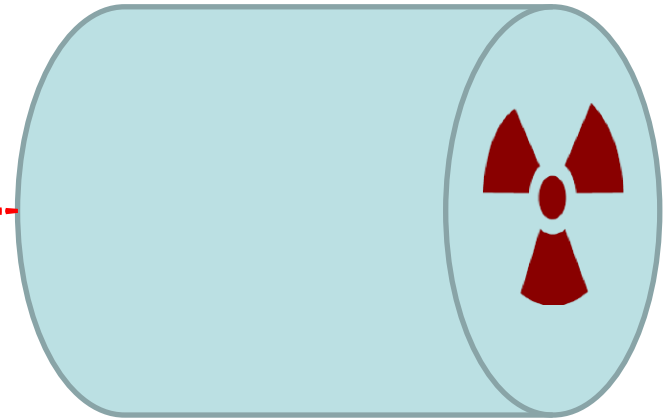
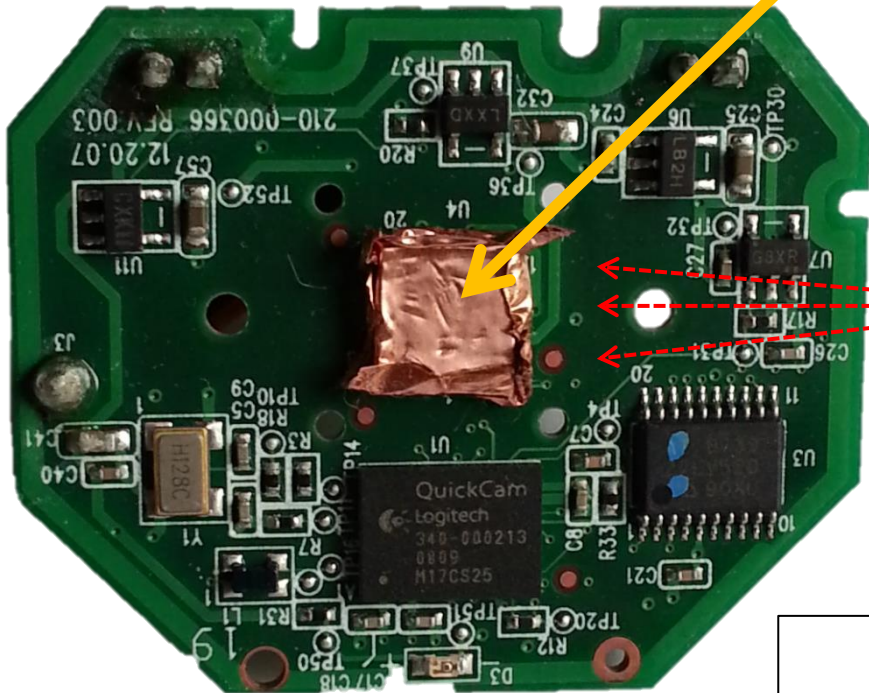


Why webcams?



Why webcams

Add metall foil to deflect light

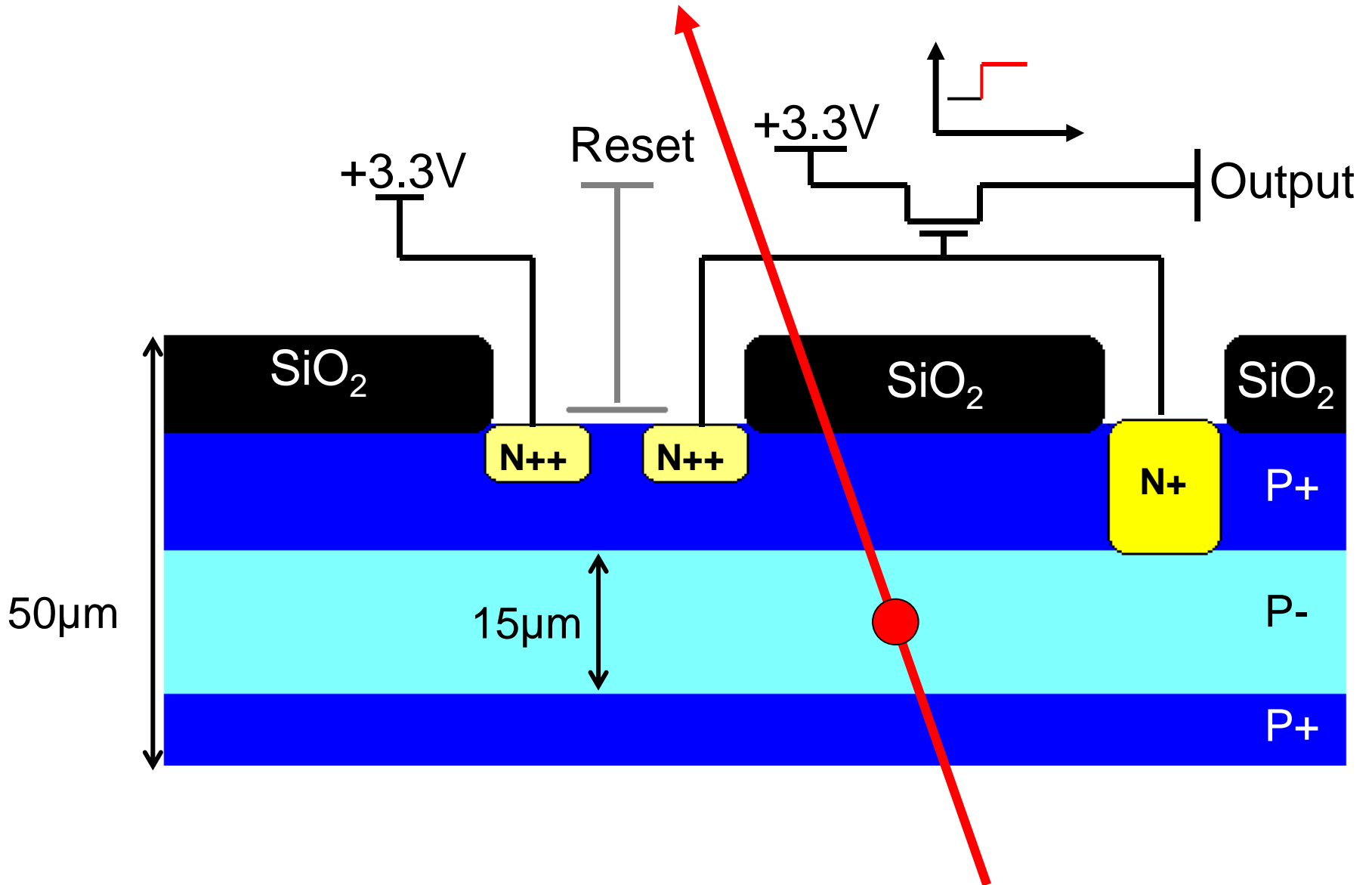


A little radioactivity
(Am-241, 60 keV photons work fine)

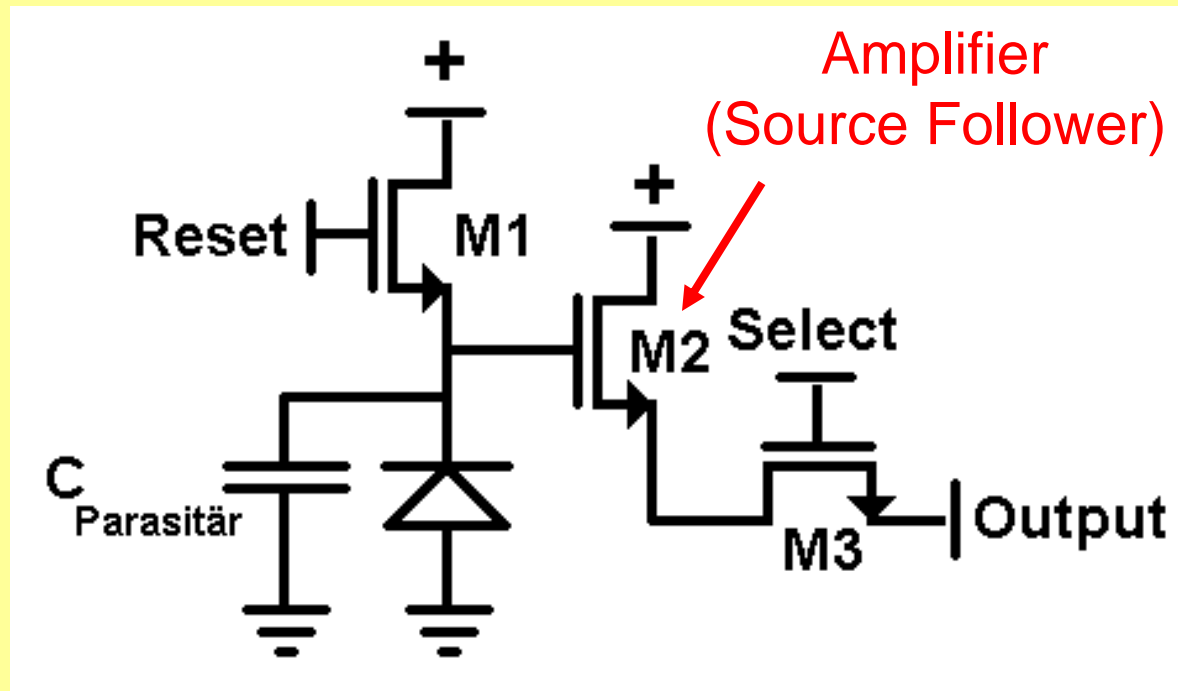
Why webcams?



How does a webcam work?

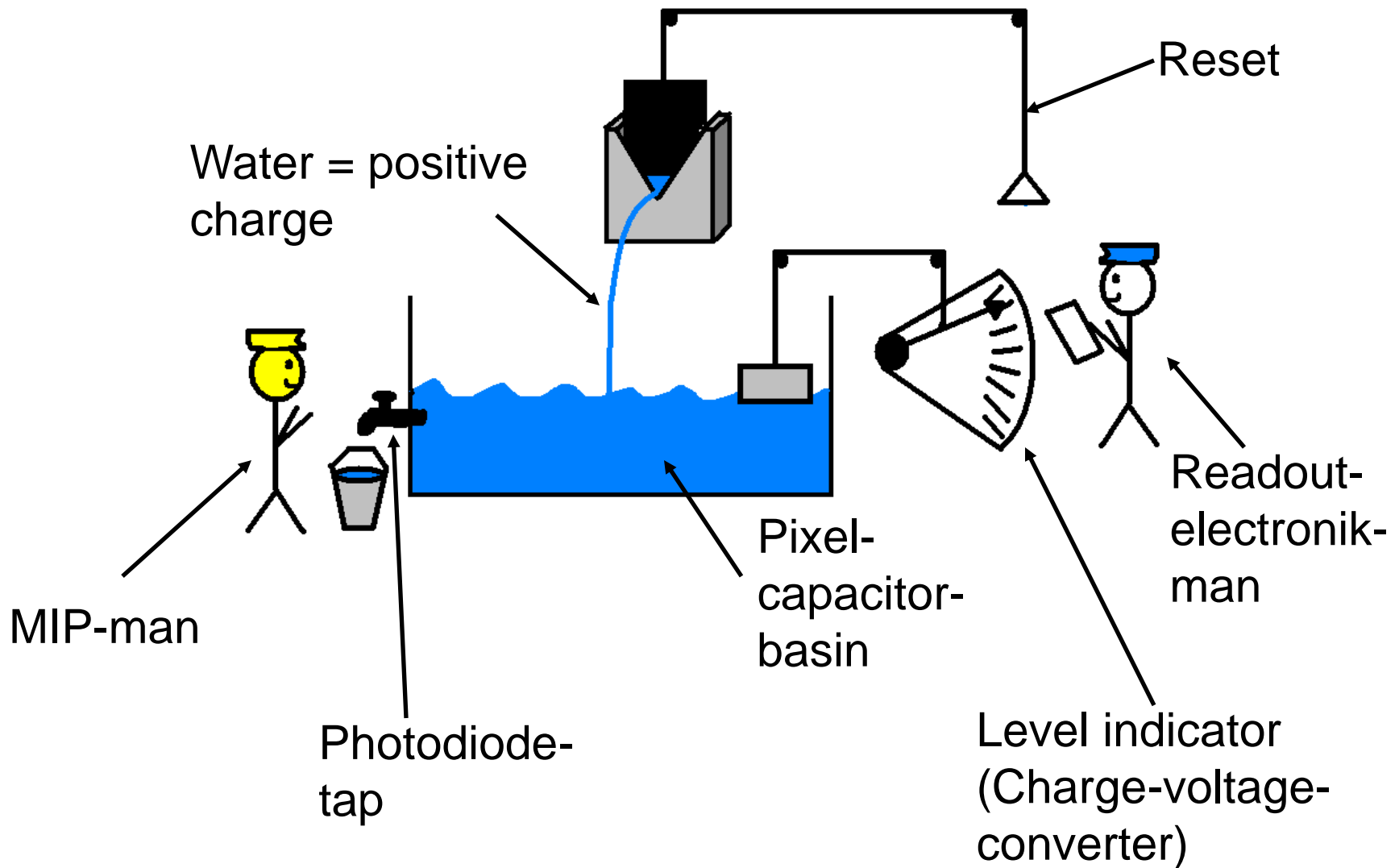


The pre-amplifier



Layout of a classical Active Pixel
(simplified)

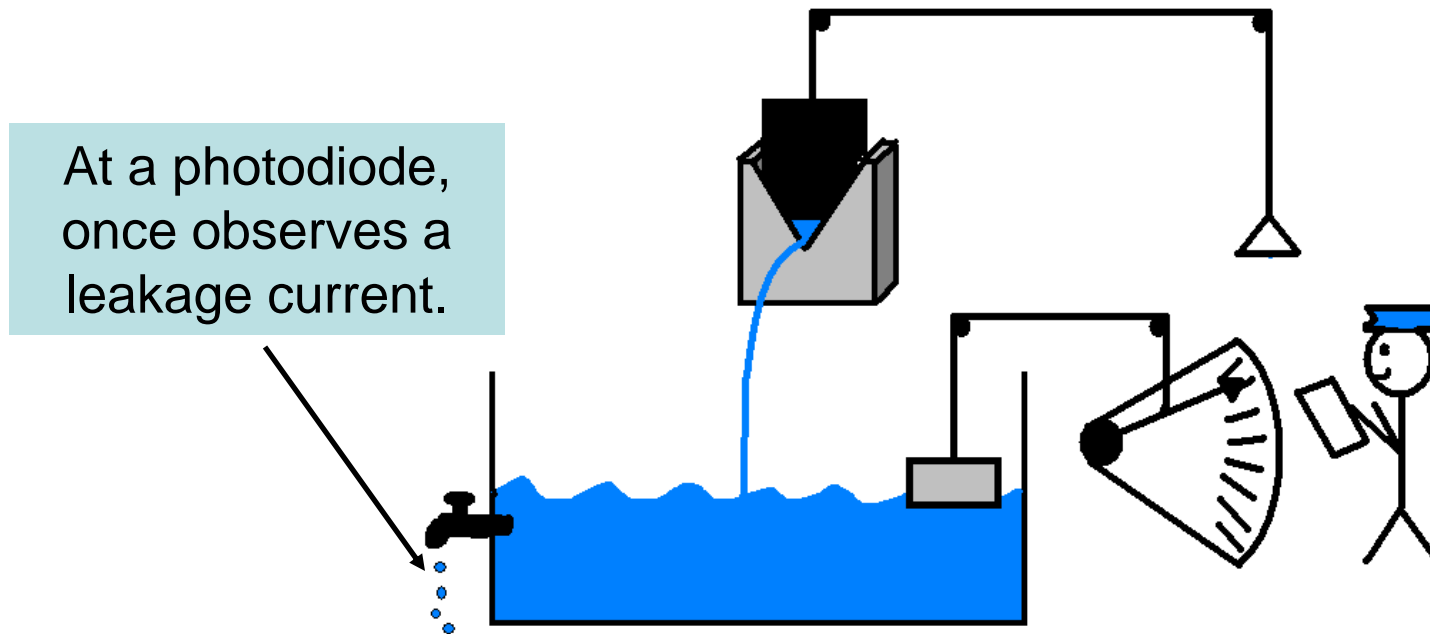
Operation principle of the pre-amplifier



Operation principle of the pre-amplifier

Readout cycle in three steps:

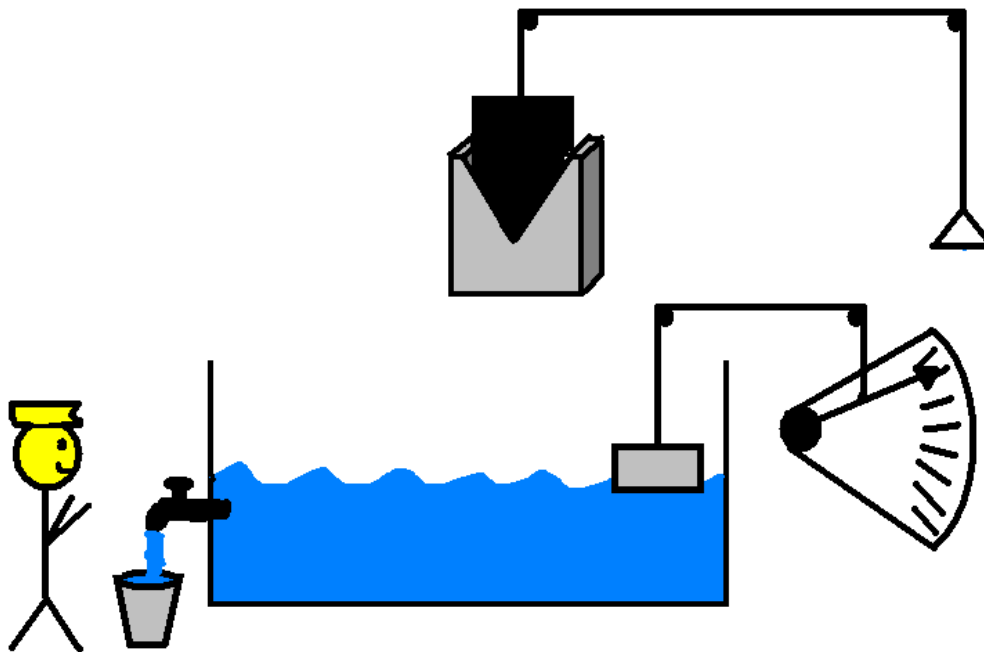
First step: Readout-electronic-Man gives a Reset



When the basin is fully recharged, the water level is noted for reference.

Operation principle of the pre-amplifier

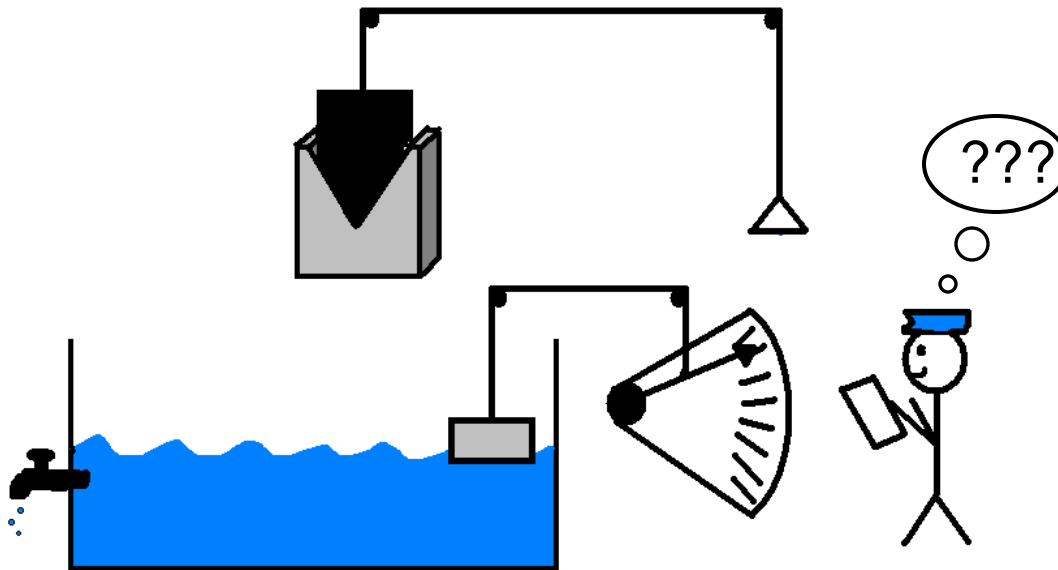
Second step: Readout-elektronic-man has care for his other pixels now



Sometimes MIP-man passes by to take bucket of positiv charge (electrons are collected by the diode after a hit).

The operation principle of the pre-amplifier

Third step: Readout-elektronik-man returns to check the water-level in the basin.



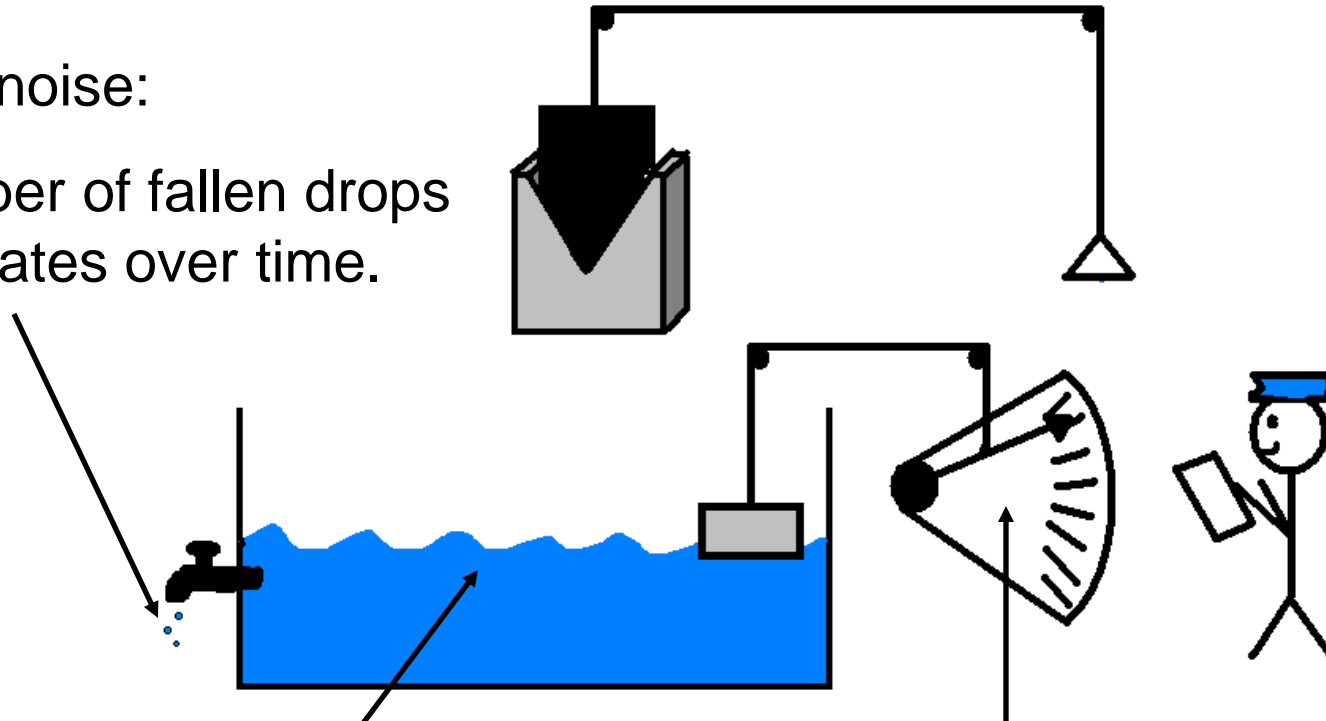
The level has dropped => MIP-man must have passed by.

MAPS pixels may measure even if they are disconnected from readout electronics and power supply.

Some sources of uncertainty

Shot noise:

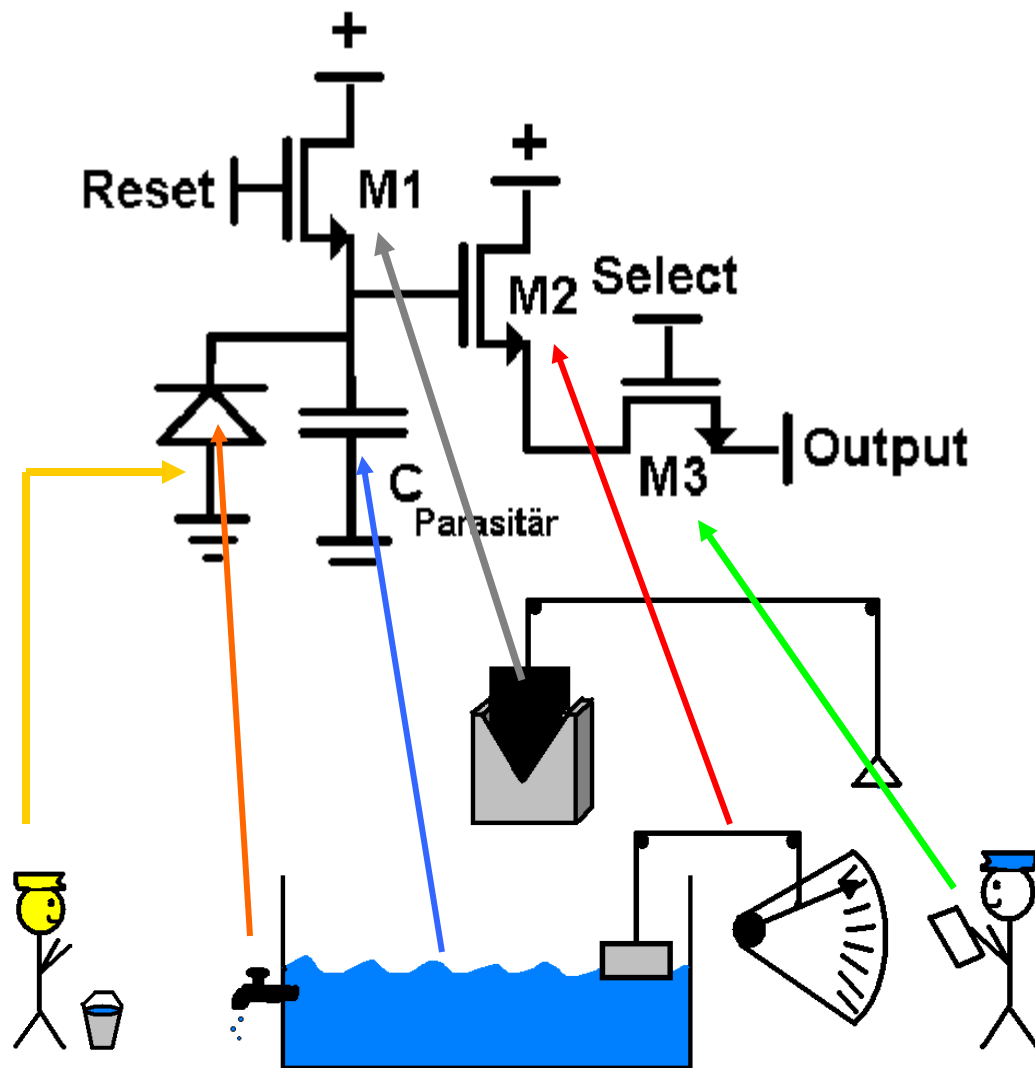
Number of fallen drops fluctuates over time.



Noise

Gain of the indicator is different for each pixel

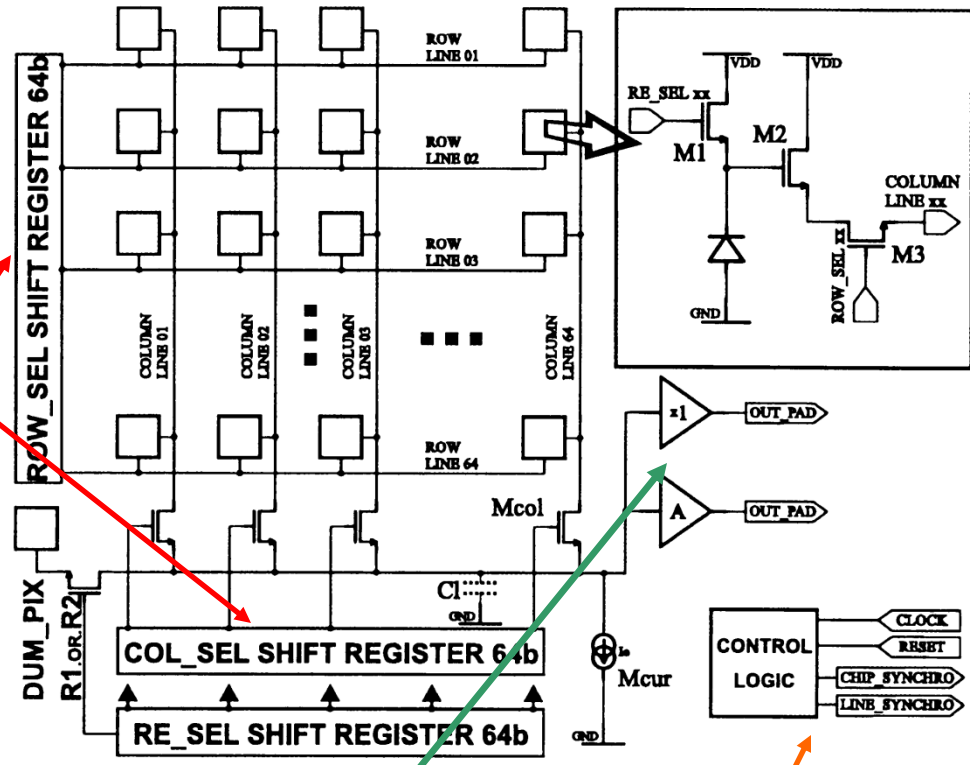
Relation between model and schematics



Readout system of early MAPS

Architecture of MIMOSA I

X- and Y-shift registers to select pixels.



Common Amplifier

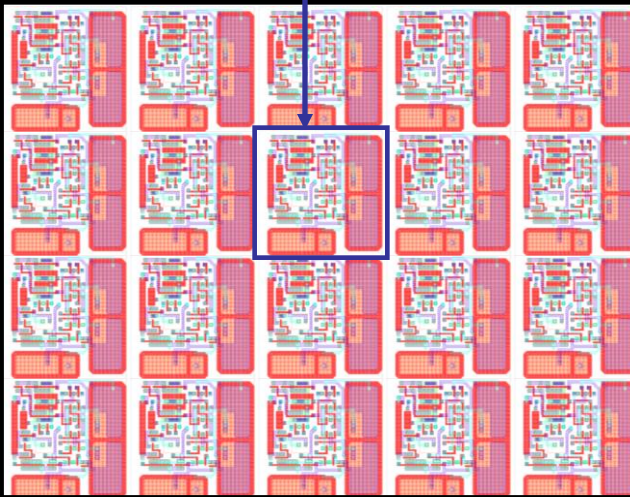
IO-Signals needed:
Clock, Reset, Synchro
and analogue output

Comparing pixel sizes

Maps-pixel
(25 x 25 μm^2)

State of the art
hybrid pixel
(100 μm x 120 μm)

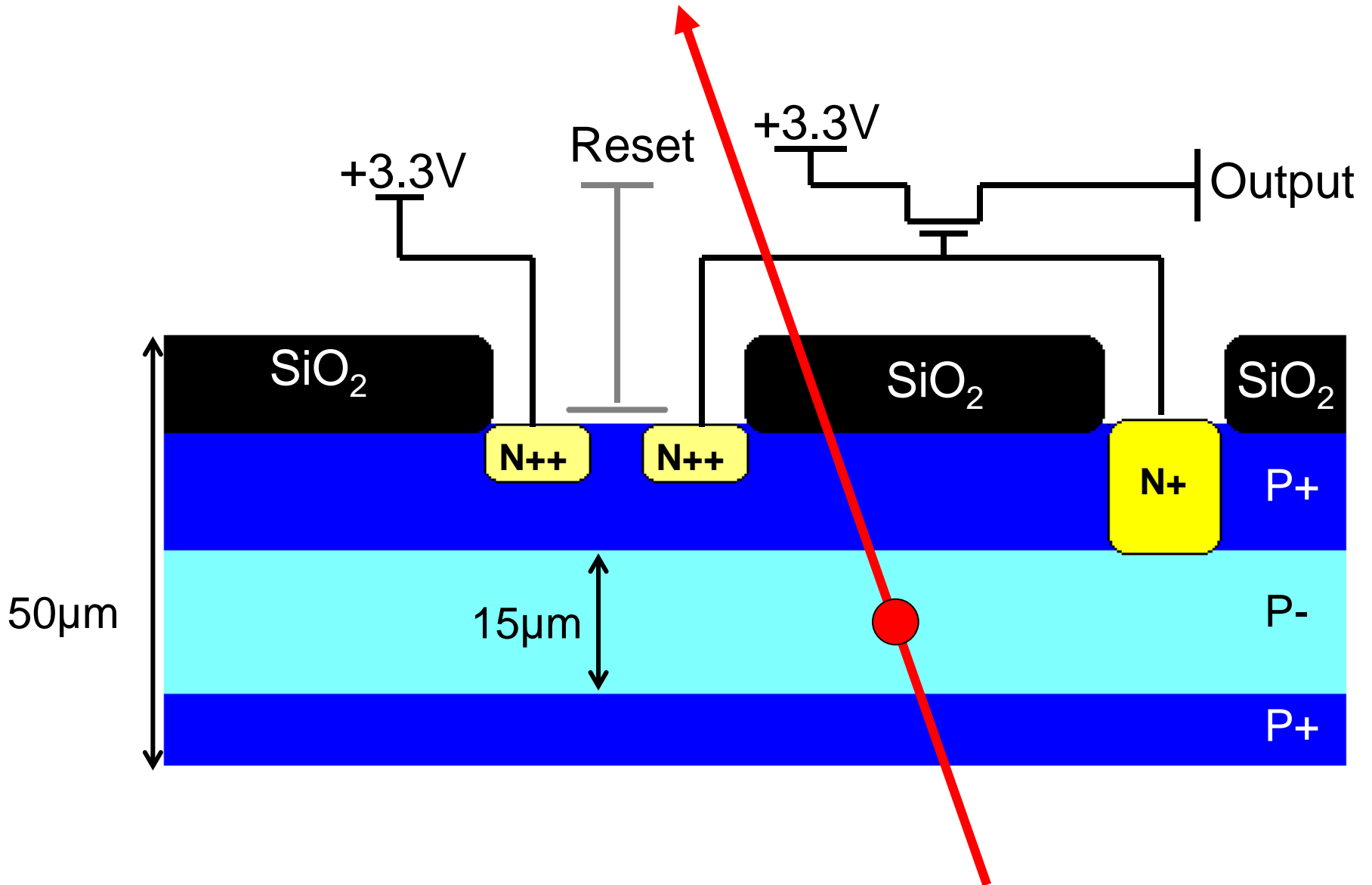
Hybrid pixel



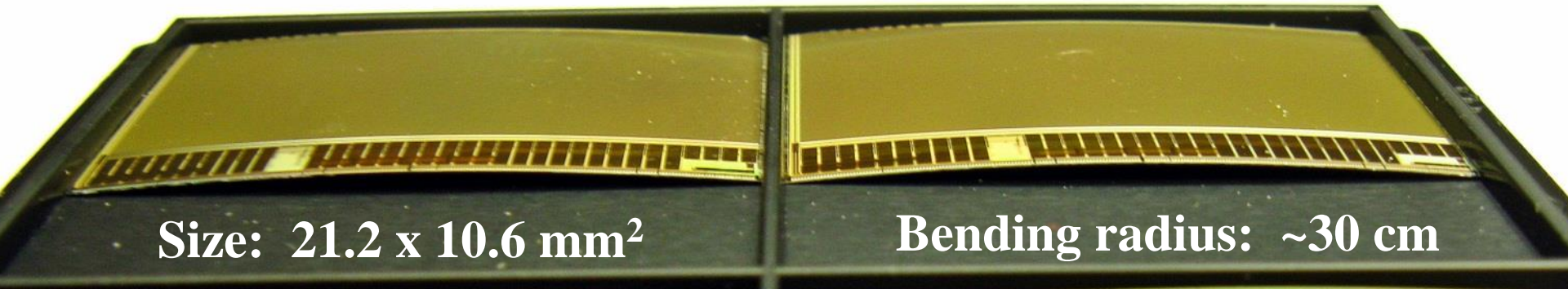
Hybrid pixel

Hybrid pixel

MAPS: The operation principle

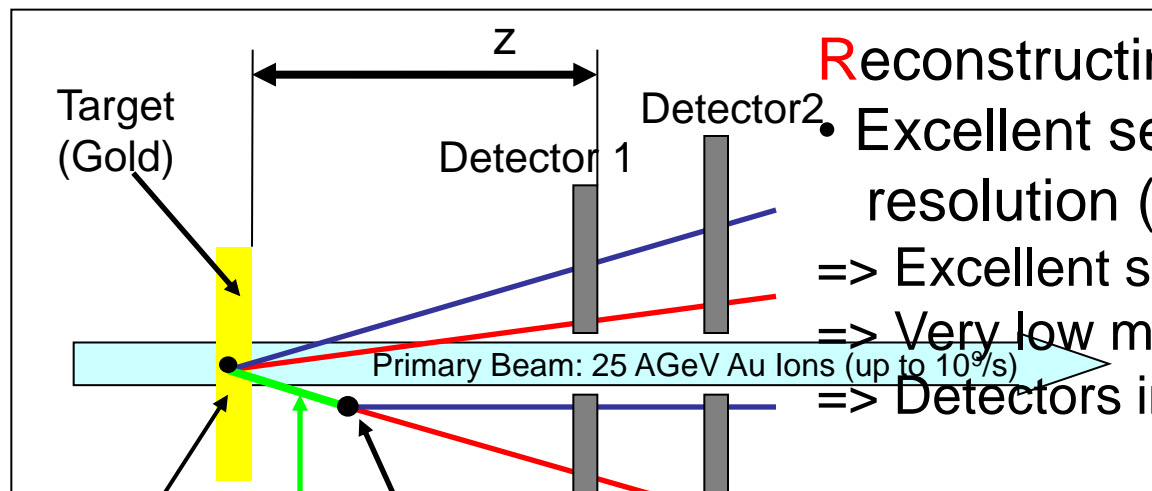


The meaning of thin...



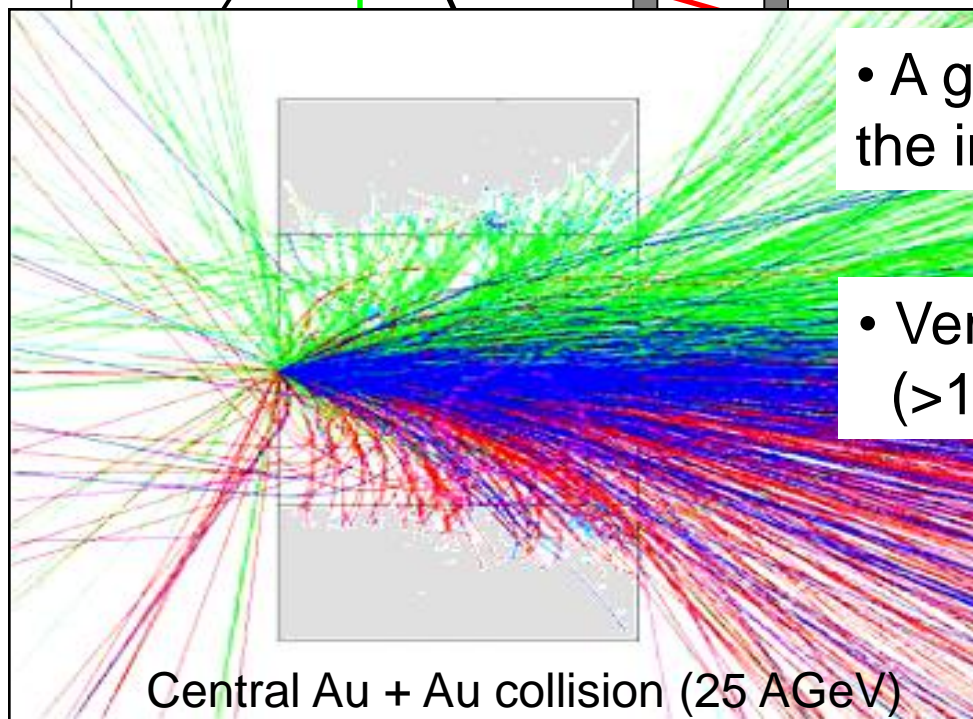
- 50 μm thickness
- Bended due to inner tensions
- Flexible silicon!

Open charm reconstruction: Concept



Reconstructing open charm requires:

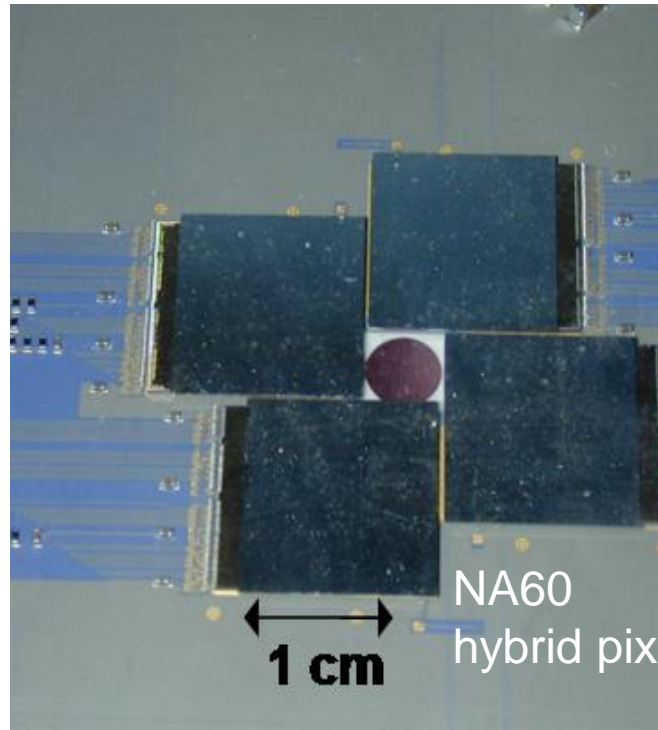
- Excellent secondary vertex resolution ($\sim 50 \mu\text{m}$)
=> Excellent spatial resolution ($\sim 5 \mu\text{m}$)
=> Very low material budget (few 0.1 % X_0)
=> Detectors in vacuum



- A good time resolution to distinguish the individual collisions (few $10 \mu\text{s}$)

- Very good radiation tolerance ($> 10^{13} n_{\text{eq}}/\text{cm}^2$)

Established pixel detector technologies (2003)



	Required (CBM)
Single point res. [μm]	~ 5
Material budget [X_0]	$\sim 0.3\%$
Time resolution [μs]	few 10
Rad. hardness [n/cm^2]	$> 10^{13}$

CCD
~ 5
$\sim 0.1\%$
~ 100
$\ll 10^{10}$

Requirements vs. detector performances (2003)

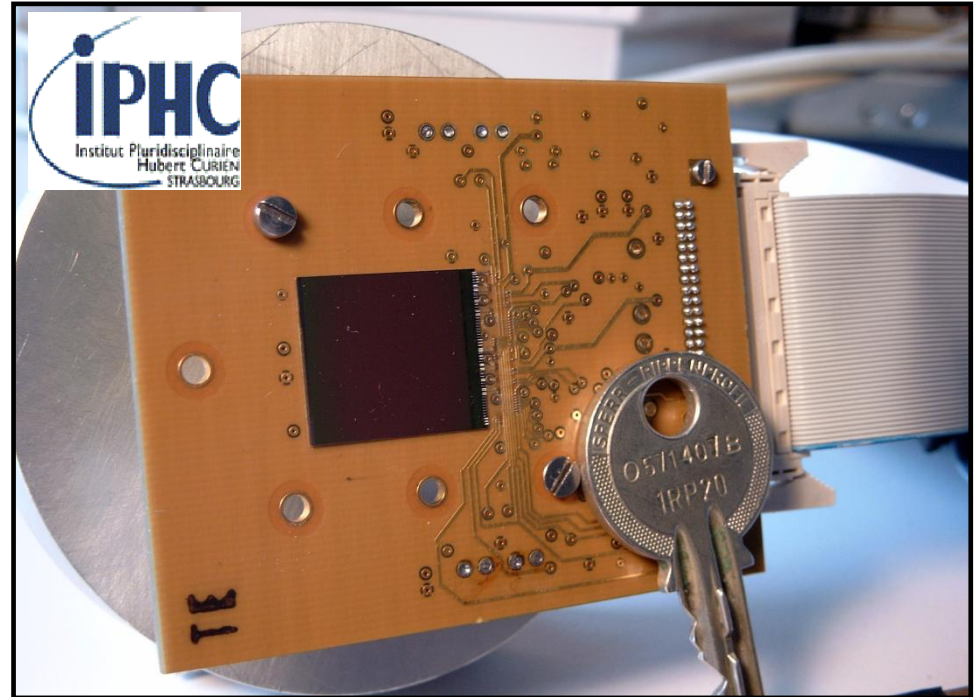


	Required	Hybrid pixels	CCD
Single point res. [μm]	~ 5	~ 30	~ 5
Material budget [X_0]	$\sim 0.3\%$	$\sim 1\%$	$\sim 0.1\%$
Time resolution [μs]	few 10	0.025	~ 100
Rad. hardness [n/cm^2]	$> 10^{13}$	$\gg 10^{14}$	$\ll 10^{10}$

Performances of MAPS (2003)

MAPS provide an unique **compromise** between:

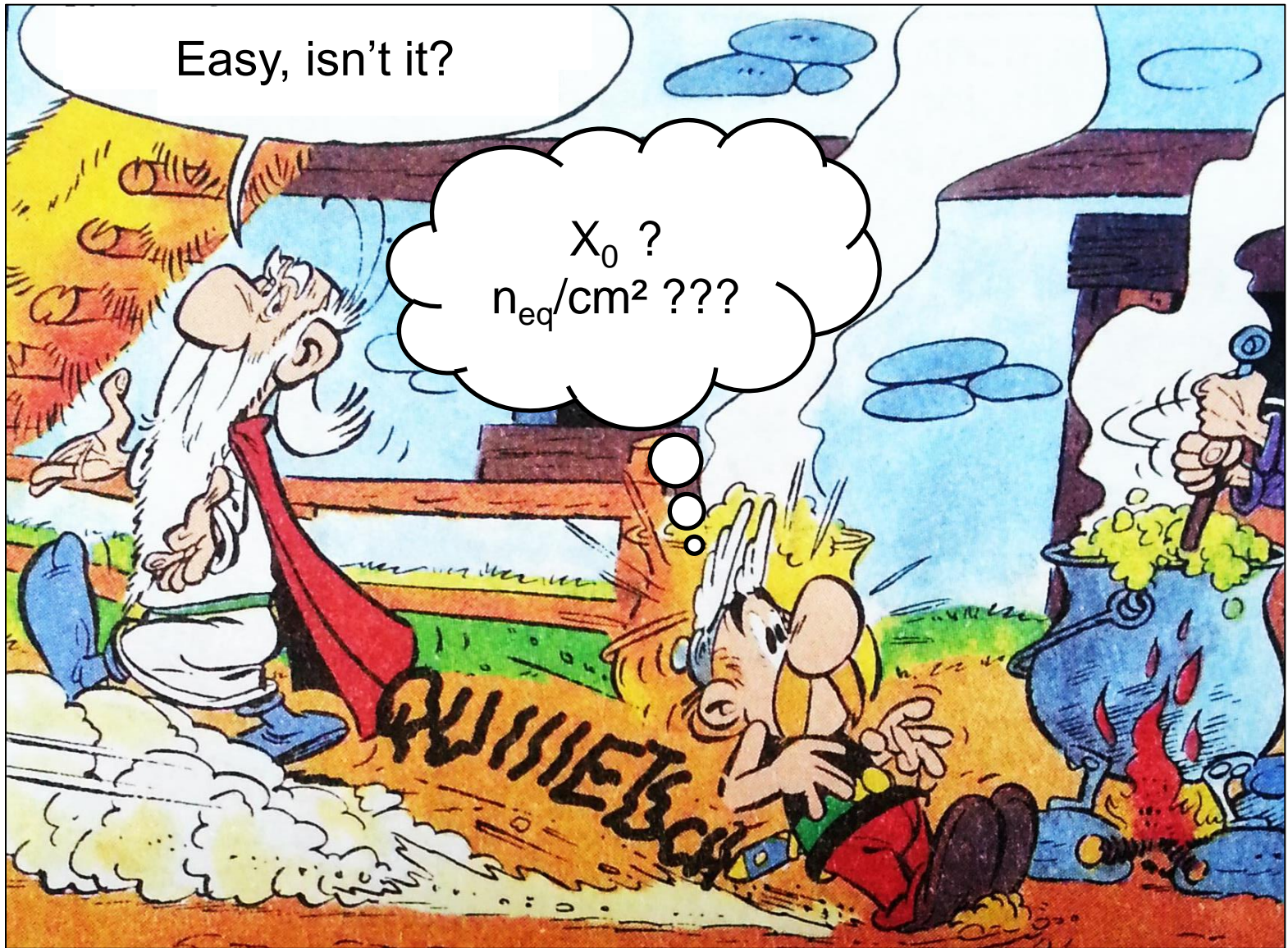
- sensitivity
- high rate capability



	Required	Hybrid pixels	CCD	MAPS** (2011)
Single point res. [μm]	~ 5	~ 30	~ 5	3.5
Material budget [X_0]	~ 0.3%	1%	~0.1%*	~0.05%*
Time resolution [μs]	few 10	0.025	~100	~10000
Rad. hardness [n/cm^2]	$> 10^{13}$	$\gg 10^{14}$	$\ll 10^{10}$	$> 10^{12}$

*Sensor only

**Best of all prototypes

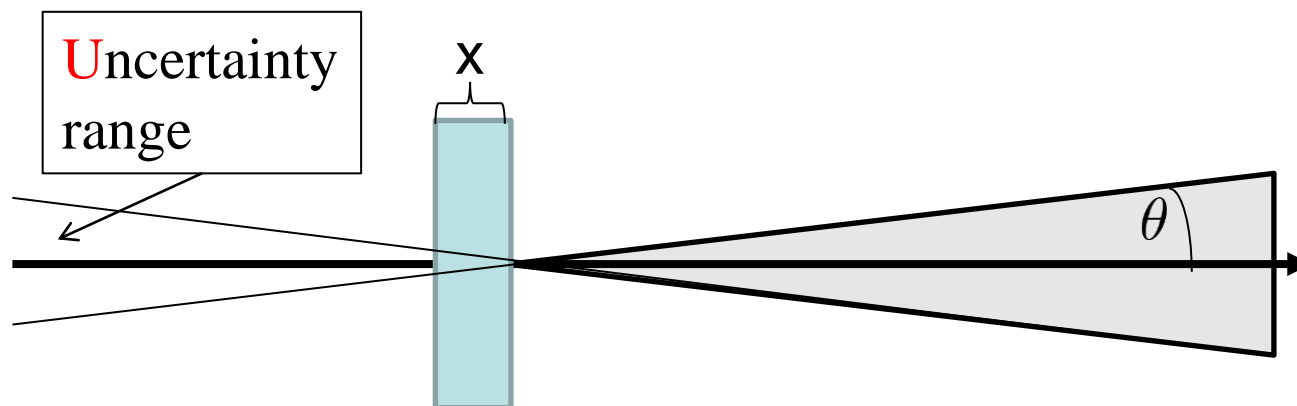


X_0 and multiple scattering

Definition of the radiation length (X_0):

- Distance in a material, which decelerates charged particles with $\gamma \gg 2000$ to 1/e of its energy.
- Material constant, tables available at <http://pdg.lbl.gov>

Relevance of the radiation length (X_0):

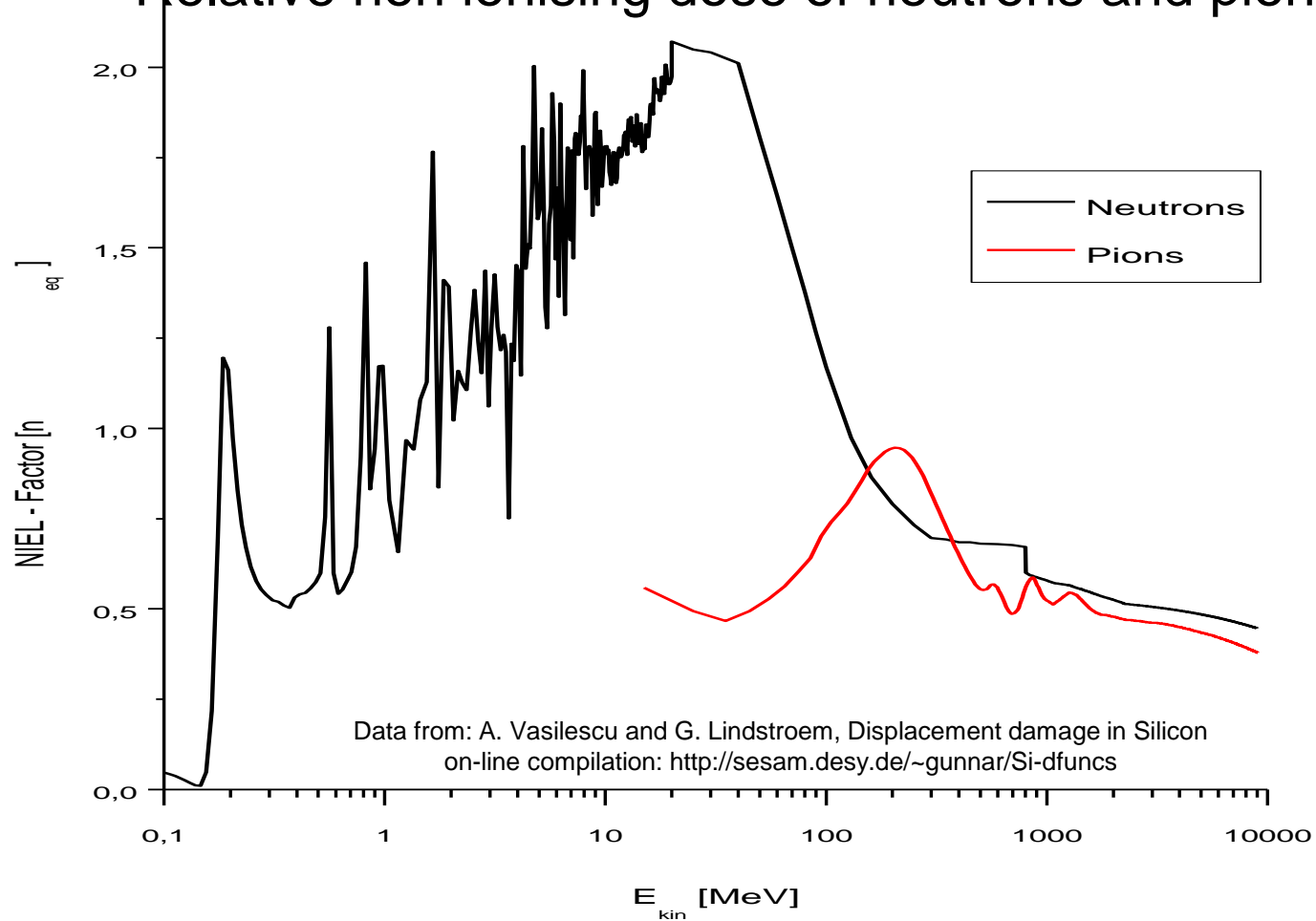


$$\theta = \frac{13.6 \text{ MeV}}{p\beta c} z \sqrt{\frac{x}{X_0}} [1 + 0.038 \ln(x/X_0)]$$

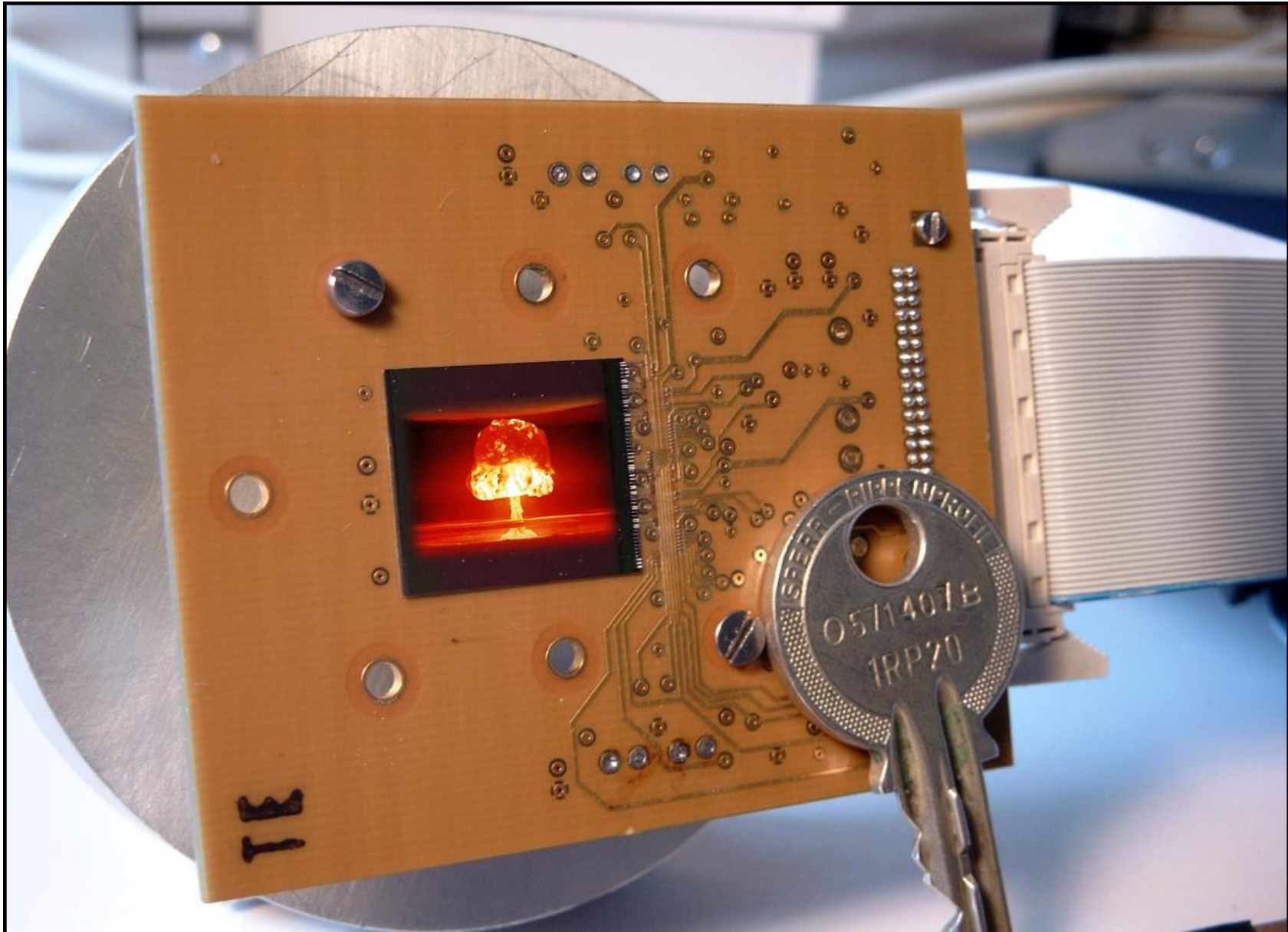
- 1) The thinner, the better.
- 2) 1% $X_0 = 1\text{mm}$ silicon

What means n_{eq}/cm^2 ?

Relative non ionising dose of neutrons and pions



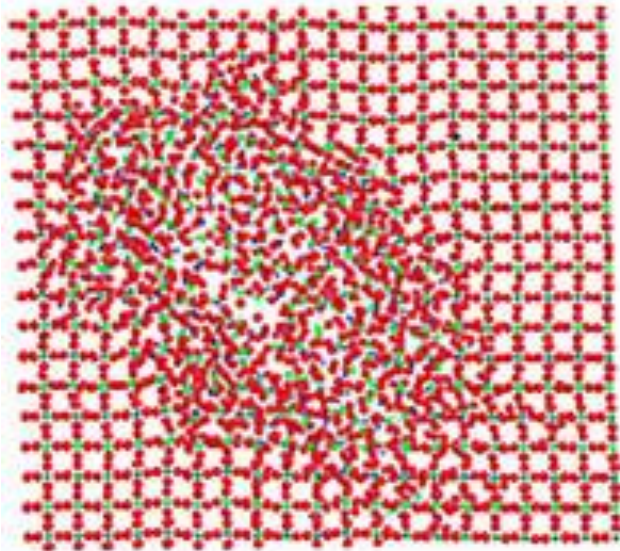
Radiation tolerance



What about radiation hardness?

Ionising radiation:

- Energy deposited into the electron cloud
- May ionise atoms and destroy molecules
- Caused by charged particles and photons

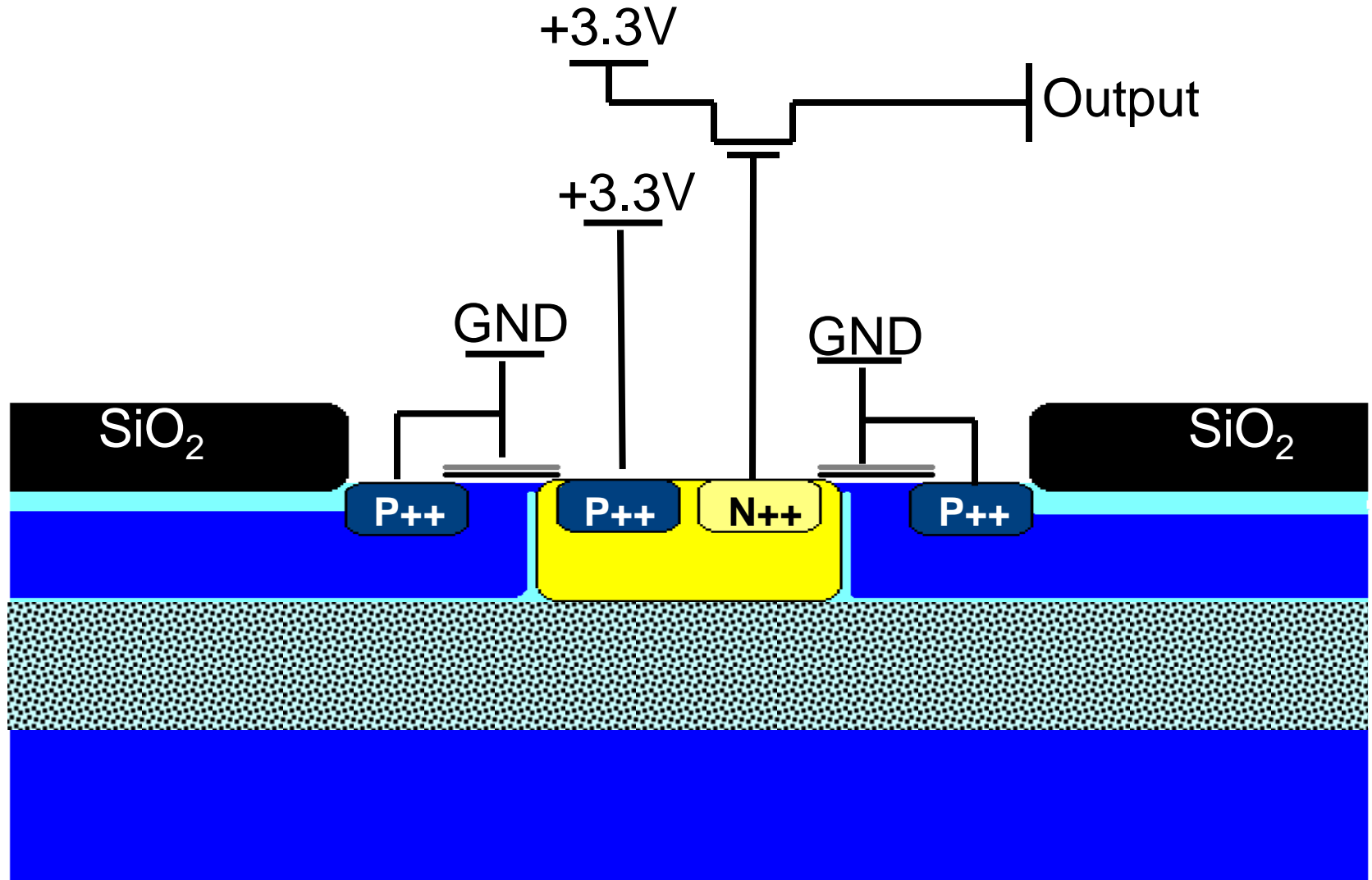


Non-ionising radiation:

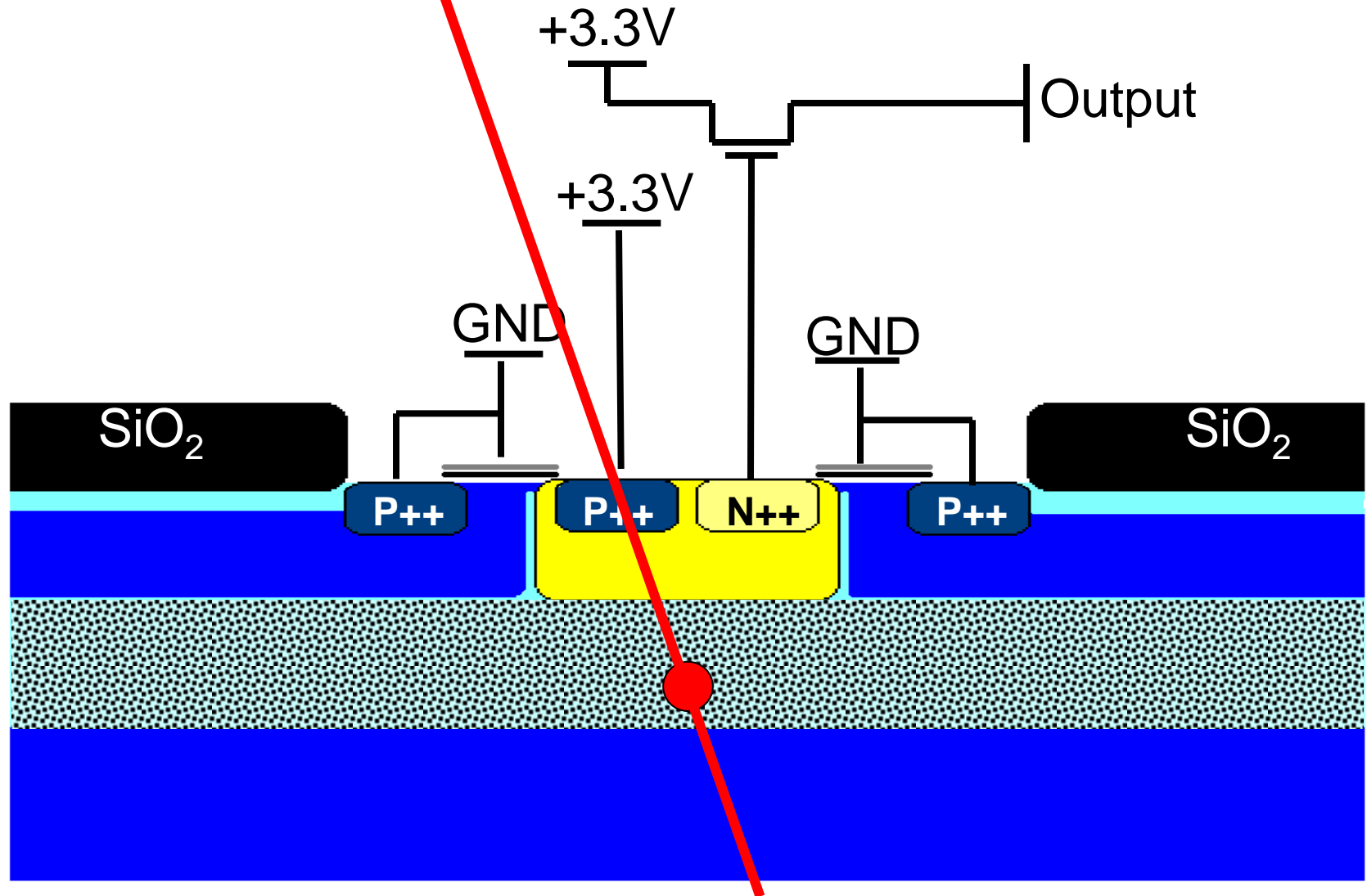
- Energy deposited into the crystal lattice
- Atoms get displaced
- Caused by heavy (fast leptons, hadrons) charged and neutral particles

Farnan I, HM Cho, WJ Weber, 2007. "Quantification of Actinide α -Radiation Damage in Minerals and Ceramics." *Nature* 445(7124):190-193.

Sensor R&D: Tolerance to non-ionising radiation

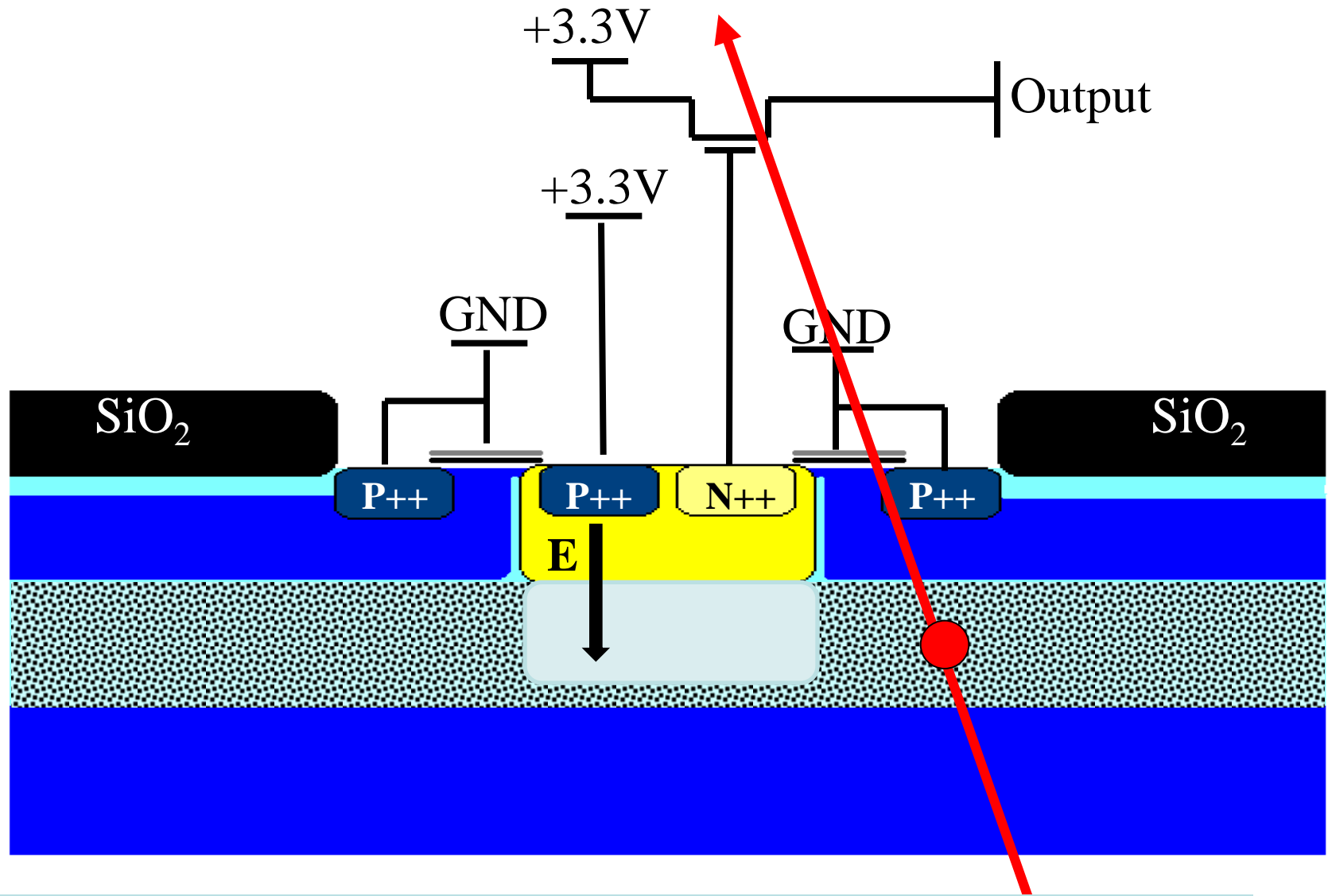


Sensor R&D: Tolerance to non-ionising radiation



Key observation: Signal amplitude is reduced by bulk damage

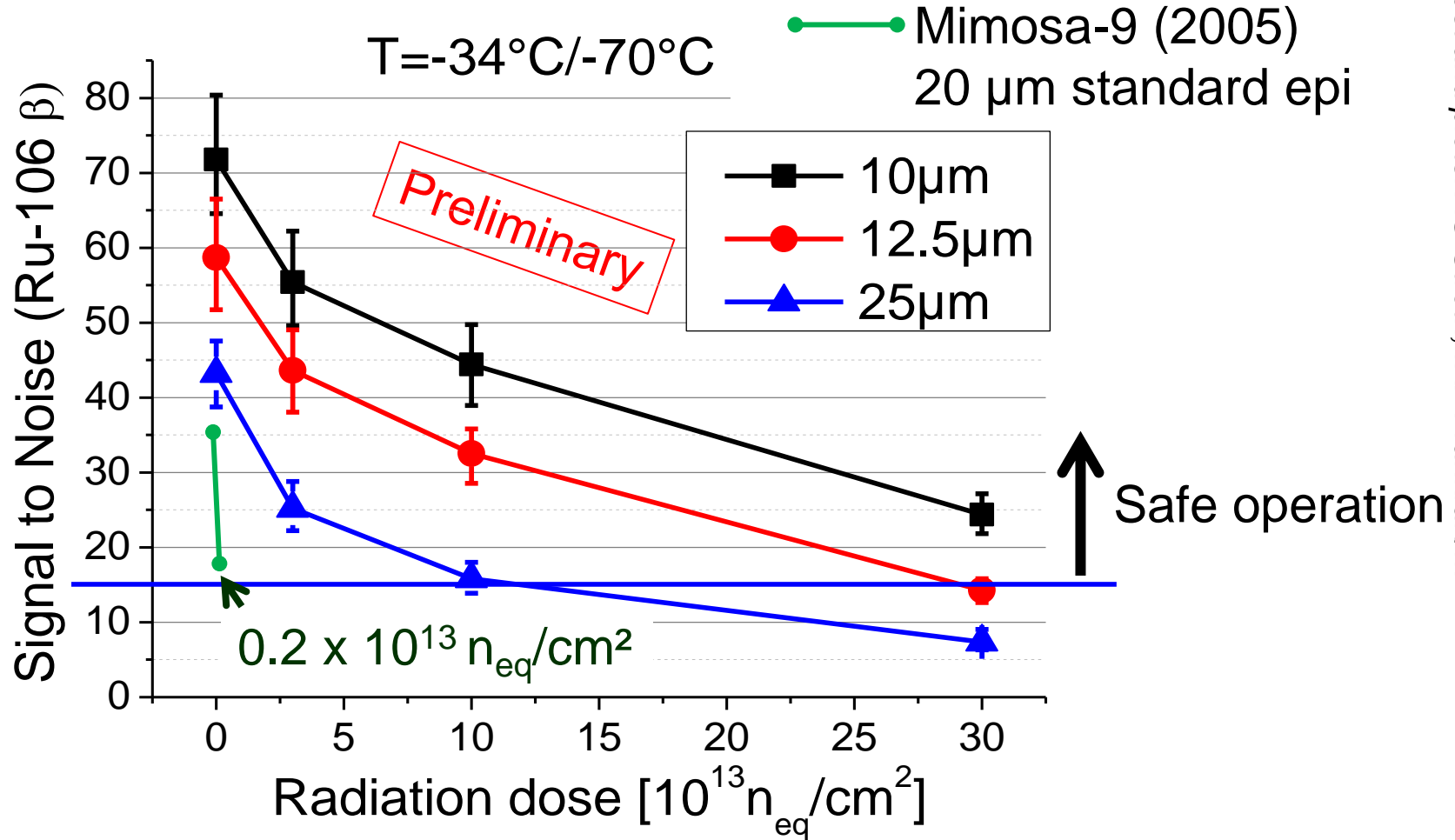
Sensor R&D: Tolerance to non-ionising radiation



Electric field increases the radiation hardness of the sensor
Draw back: Need CMOS-processes with low doping epitaxial layer

S/N of MIMOSA-18 AHR (high resistivity epi-layer)

D. Doering, P. Scharrer, M. Domachowski

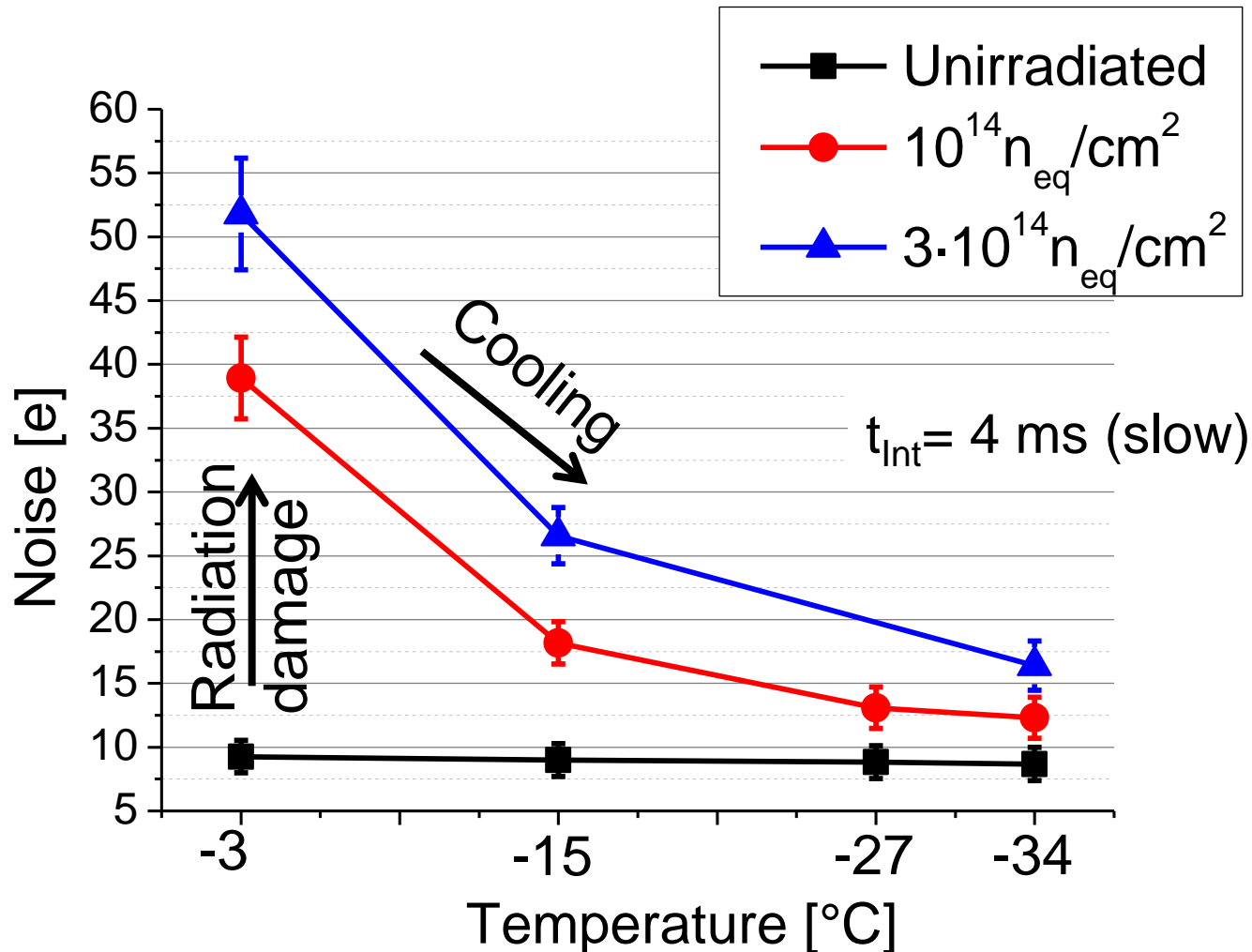


Sensor design: PICSEL Group, IPHC Strasbourg, et al.
Sensor test and plots: AG Stroth, IKF Frankfurt/M

Plausible conclusion: Radiation tolerance $\sim 10^{14}$ n_{eq}/cm² reached

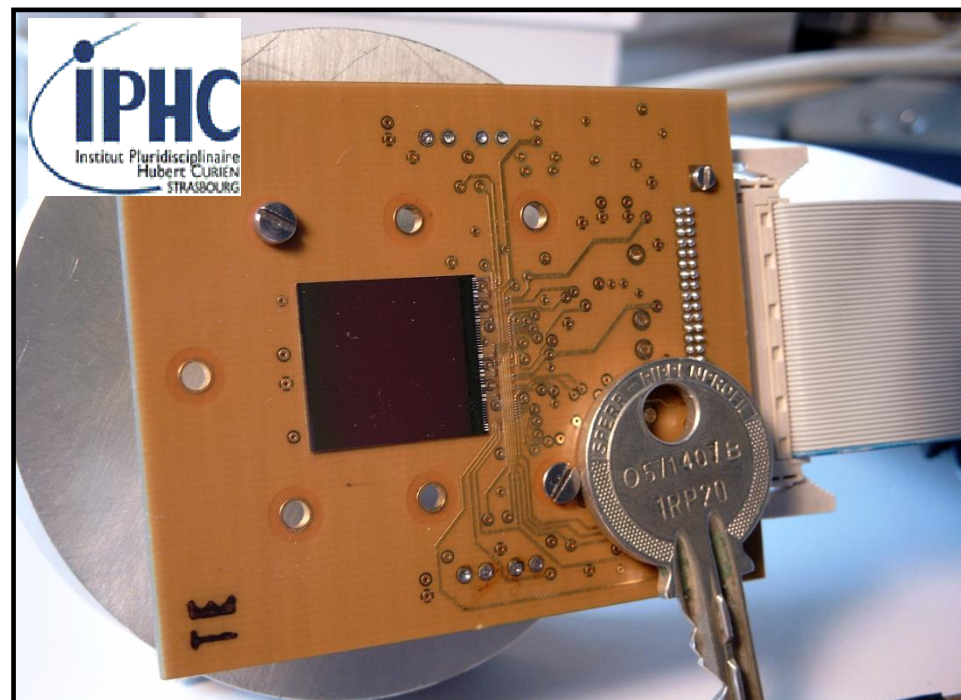
- Cooling required to operate heavily irradiated sensors

Noise and cooling



Cooling is needed to exploit the improved radiation tolerance
Alternative solution: Fast integration times help

Performances of MAPS



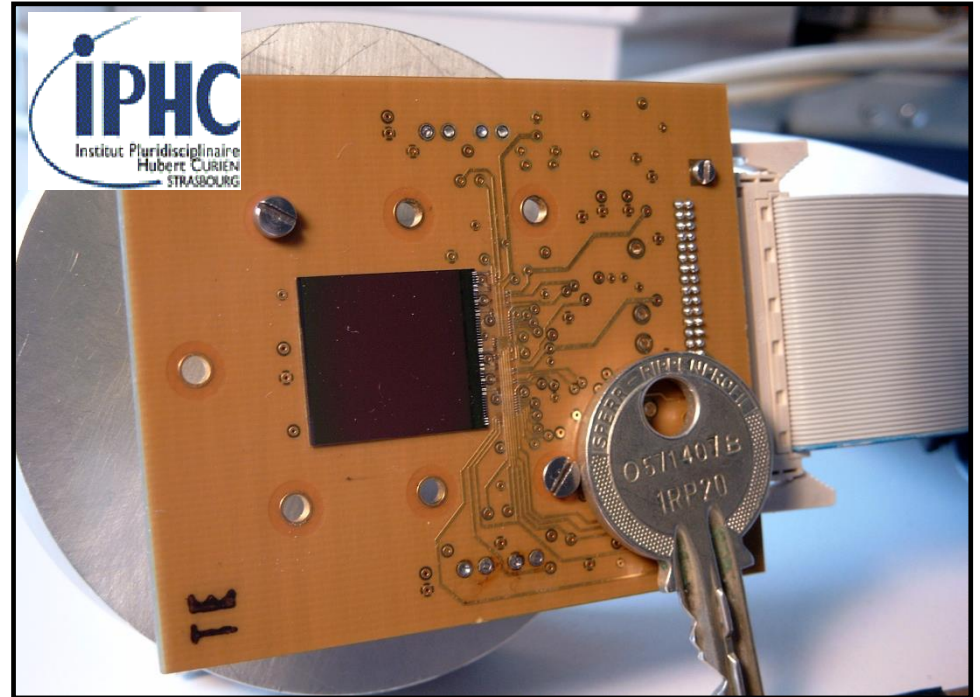
Sensor design: PICSEL Group, IPHC Strasbourg, et al.
 Sensor test and plots: AG Stroth, IKF Frankfurt/M

	Required	Hybrid pixels	CCD	MAPS** (2011)
Single point res. [μm]	~ 5	~ 30	~ 5	3.5
Material budget [X_0]	~ 0.3%	1%	~0.1%*	~0.05%*
Time resolution [μs]	few 10	0.025	~100	~10000
Rad. hardness [n/cm^2]	$> 10^{13}$	$\gg 10^{14}$	$\ll 10^{10}$	$> 10^{12}$

*Sensor only

**Best of all prototypes

Performances of MAPS



Sensor design: PICSEL Group, IPHC Strasbourg, et al.
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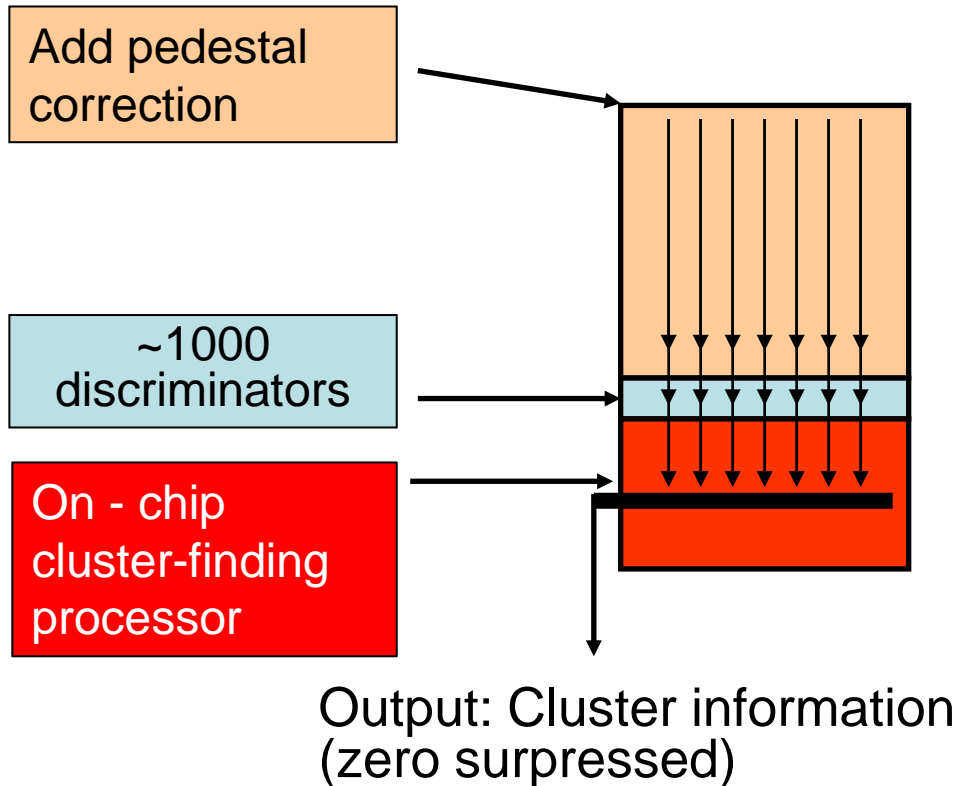
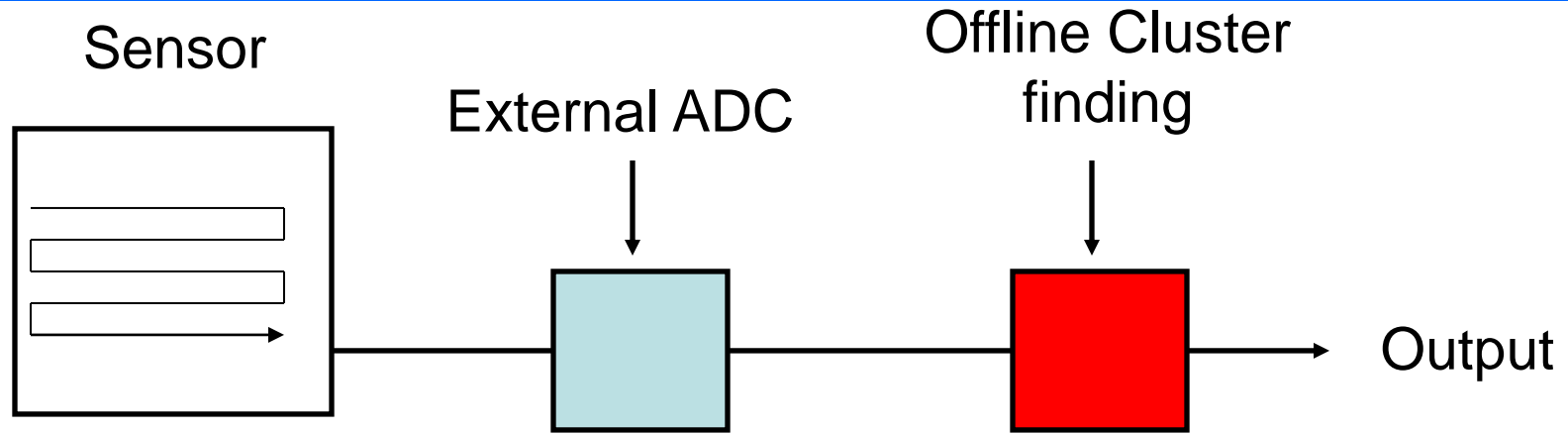
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Time resolution [μs]	few 10	0.025	~100	~10000
Rad. hardness [n/cm^2]	$> 10^{13}$	$\gg 10^{14}$	$\ll 10^{10}$	~ 10^{14}

*Sensor only

**Best of all prototypes



Sensor R&D: How to gain speed



MAPS are built in CMOS technology

Allows to integrate:

- sensor
 - analog circuits
 - digital circuits
- on one chip.

Sensor R&D: How to gain speed

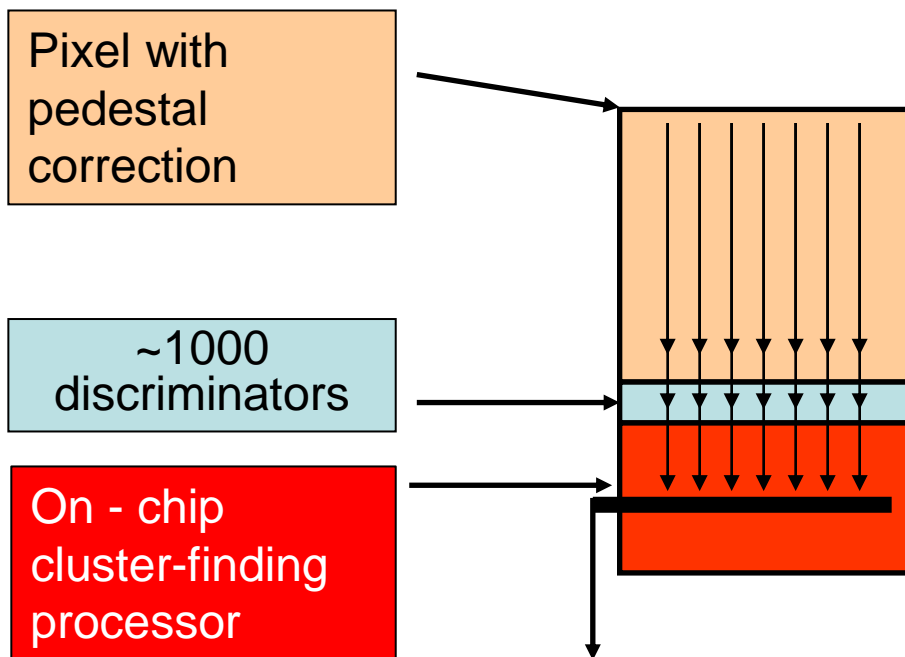
Serial readout

parallel

	MIMOSA-1 (2000)	MIMOSA-5 (2002)	MIMOSA-20 (2006)
Readout	Serial	Serial	Serial Mk. 2
Pixel/line/s	5M	20M	50M

Data/sensor: 1200 Mbps

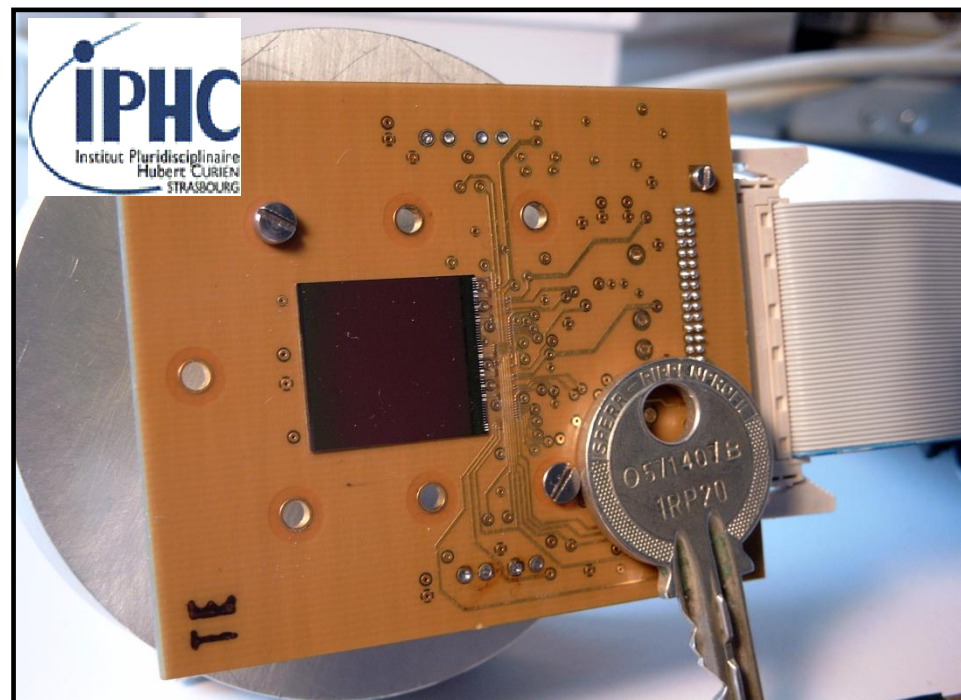
160 Mbps



Output: Cluster information
(zero suppressed)

Readout time before: 1-20 ms
 Readout time now: ~100 μ s
 Improve further with shorter columns.

Performances of MAPS



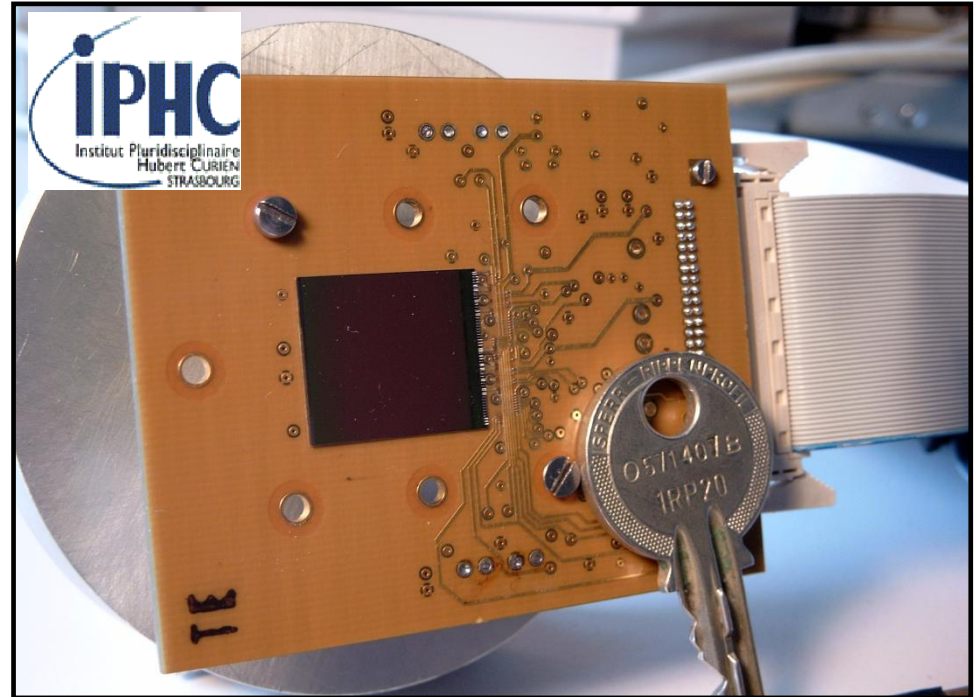
	Required	Hybrid pixels	CCD	MAPS** (2011)
Single point res. [μm]	~ 5	~ 30	~ 5	3.5
Material budget [X_0]	~ 0.3%	1%	~0.1%*	~0.05%*
Time resolution [μs]	few 10	0.025	~100	~10000
Rad. hardness [n/cm^2]	$> 10^{13}$	$\gg 10^{14}$	$\ll 10^{10}$	~ 10^{14}

*Sensor only

**Best of all prototypes



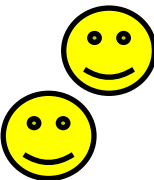
Performances of MAPS



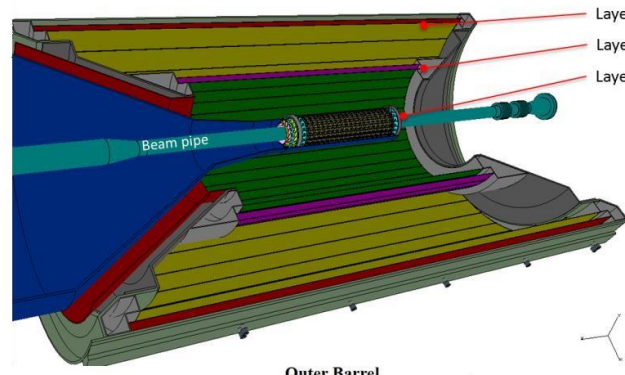
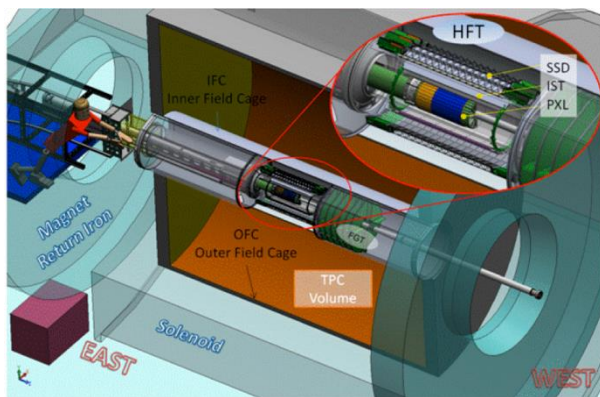
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Single point res. [μm]	~ 5	~ 30	~ 5	3.5
Material budget [X_0]	~ 0.3%	1%	~0.1%*	~0.05%*
Time resolution [μs]	few 10	0.025	~100	30-100
Rad. hardness [n/cm^2]	$> 10^{13}$	$\gg 10^{14}$	$\ll 10^{10}$	~ 10^{14}

*Sensor only

**Best of all prototypes



Applications of MAPS



STAR HFT

ALICE ITS?



2008

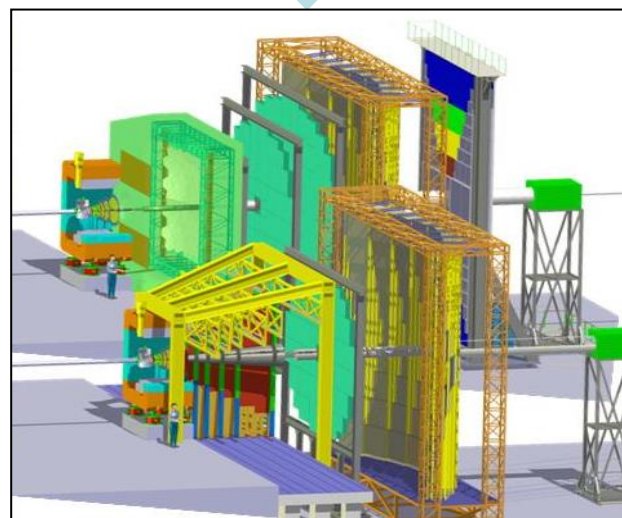
2013

2018

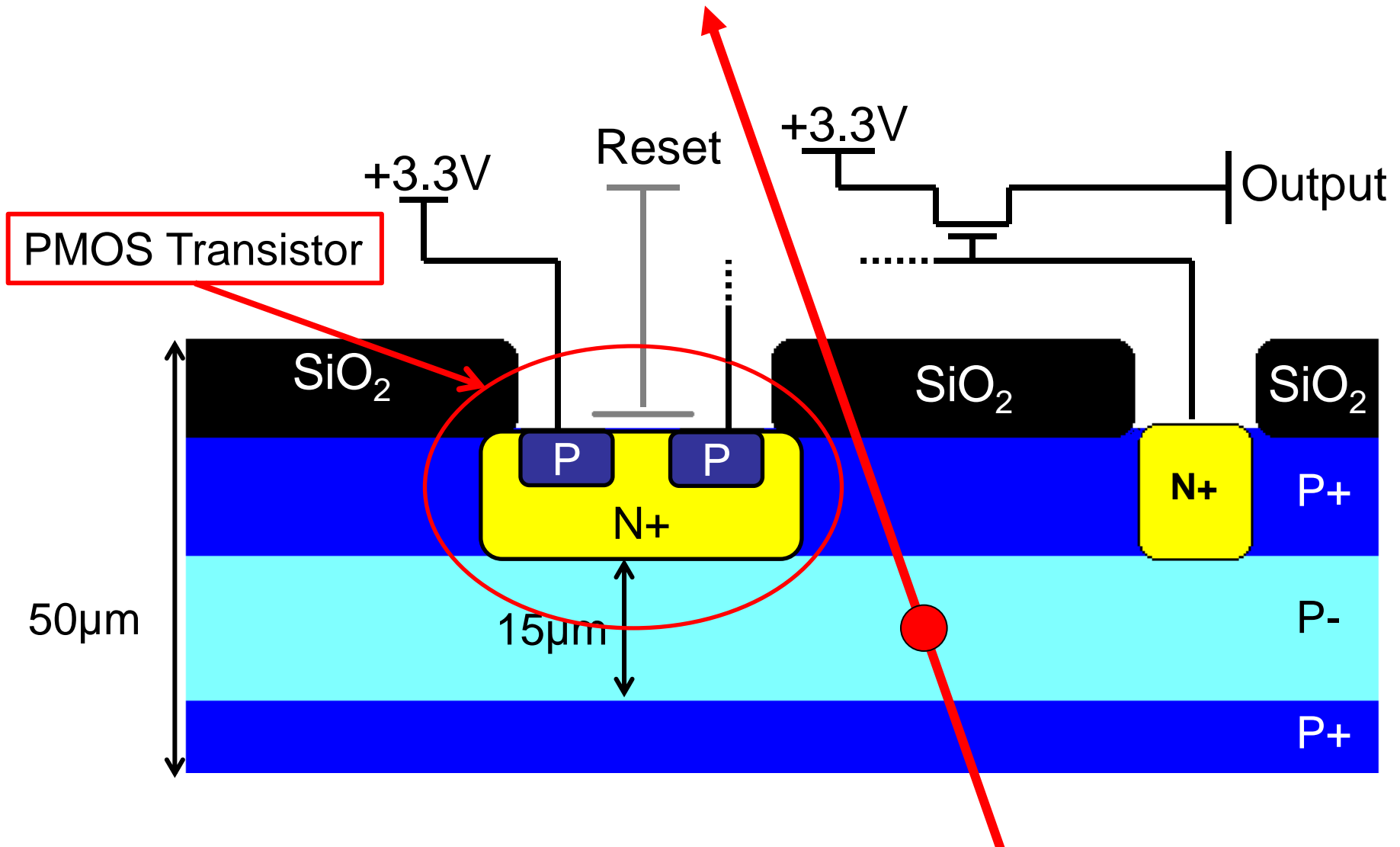
ILC?

EUDet
Telescope

CBM MVD

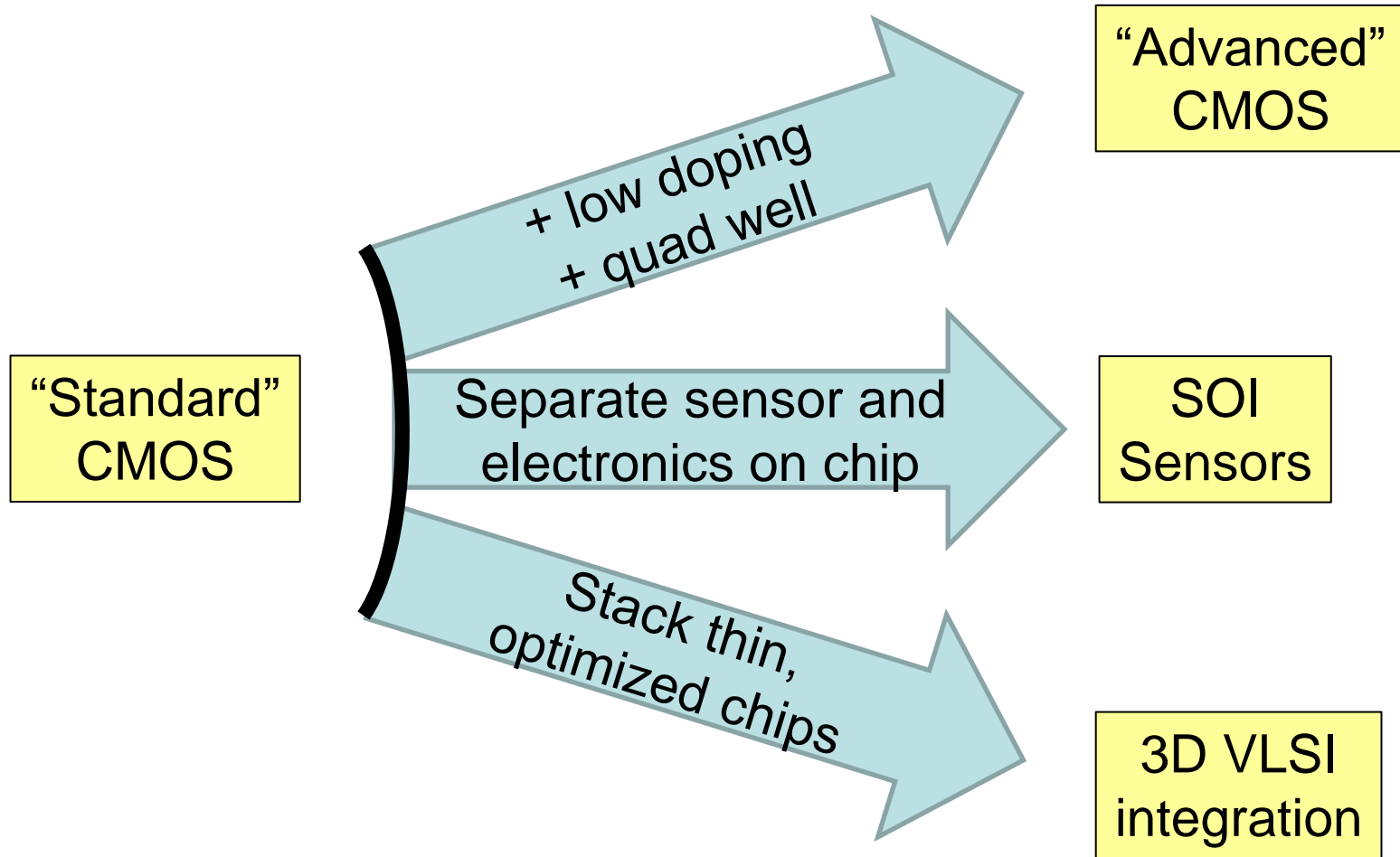


Need for Speed II: A new generation at the horizon

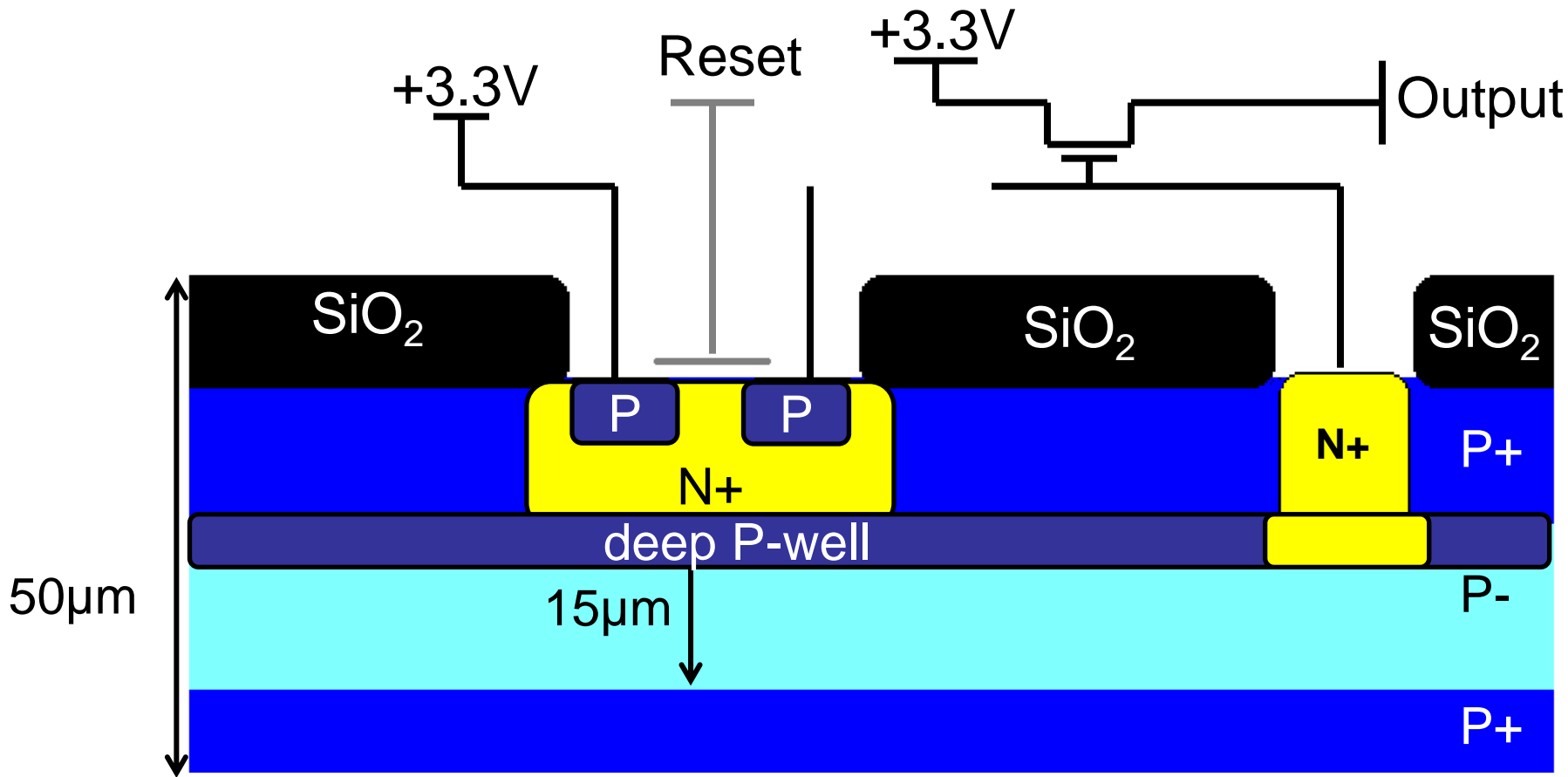


In standard CMOS sensors, no PMOS transistors are possible in pixel
=> No high level functions like discriminators ... => "slow"

Going beyond rolling shutter



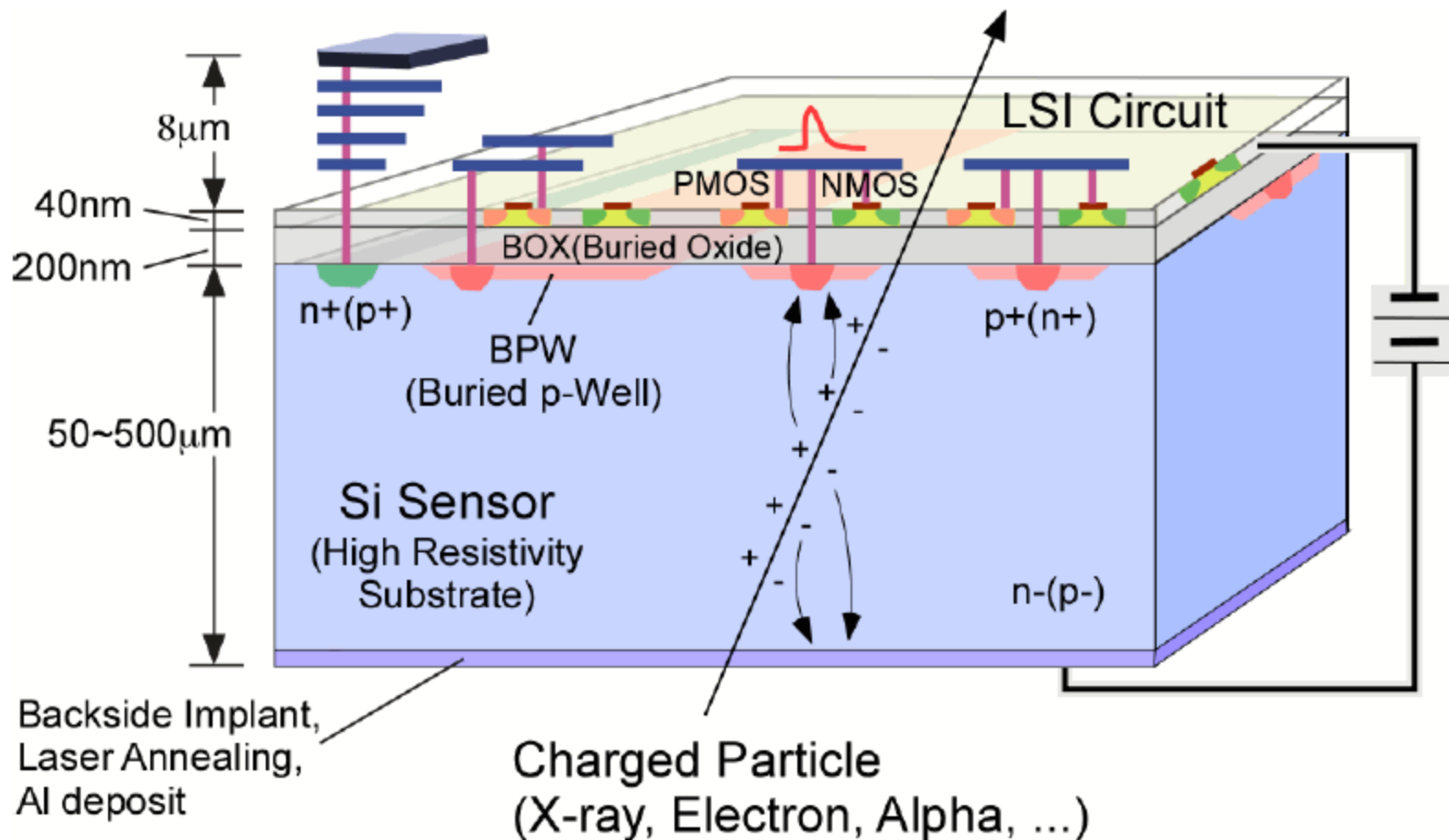
Advanced CMOS



Players among others: PICSEEL Group, IPHC Strasbourg, et al.

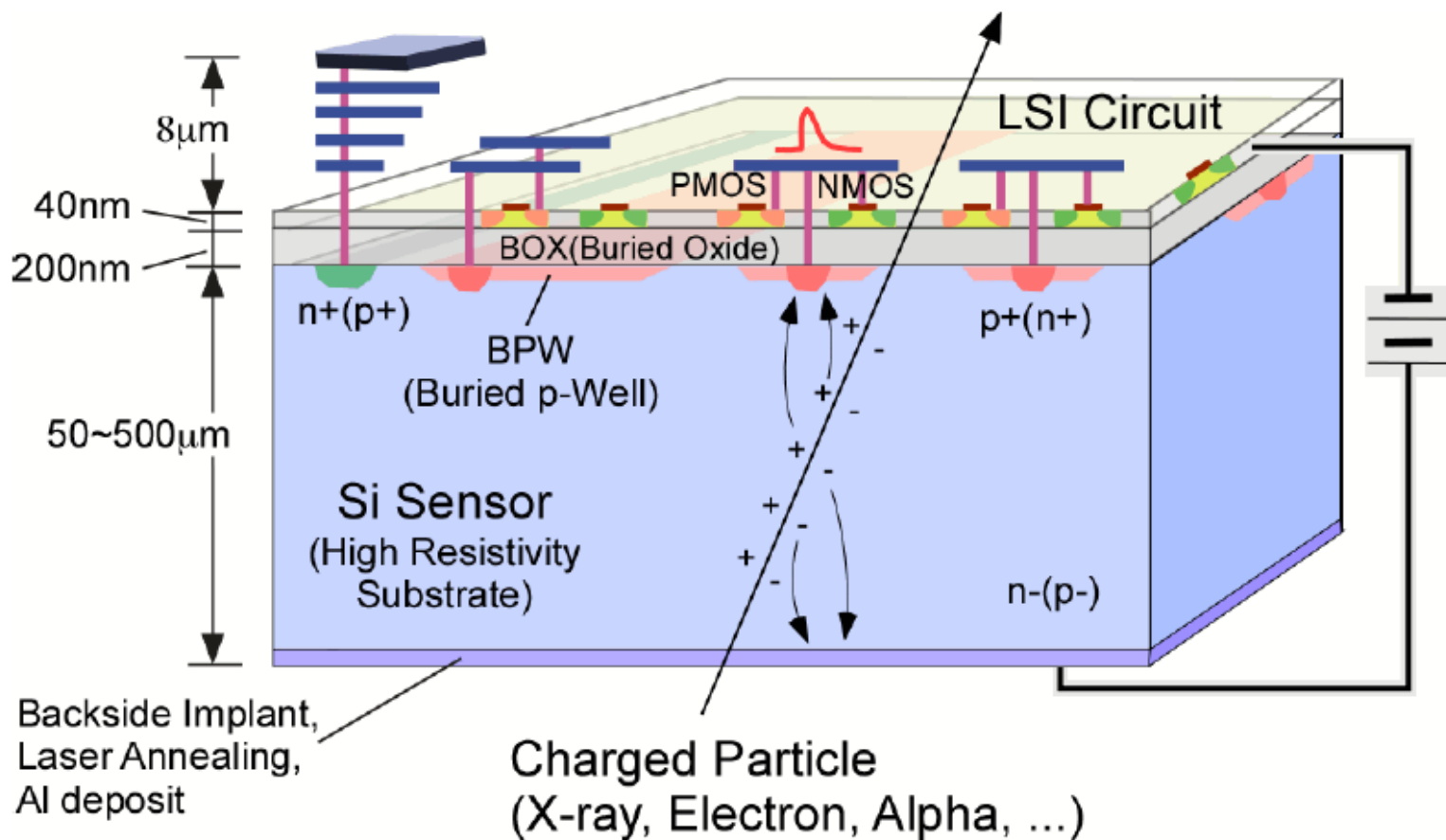
- Full CMOS is reached in modern 0.18µm processes with quad-well
Exploited for IPHC – AROM sensors (discriminator on pixel)
- + Simple, cost efficient, widely available in industry
 - + Industrial trend toward better epitaxial layers
 - On pixel electronics limited by pixel surface

SOI - Pixels



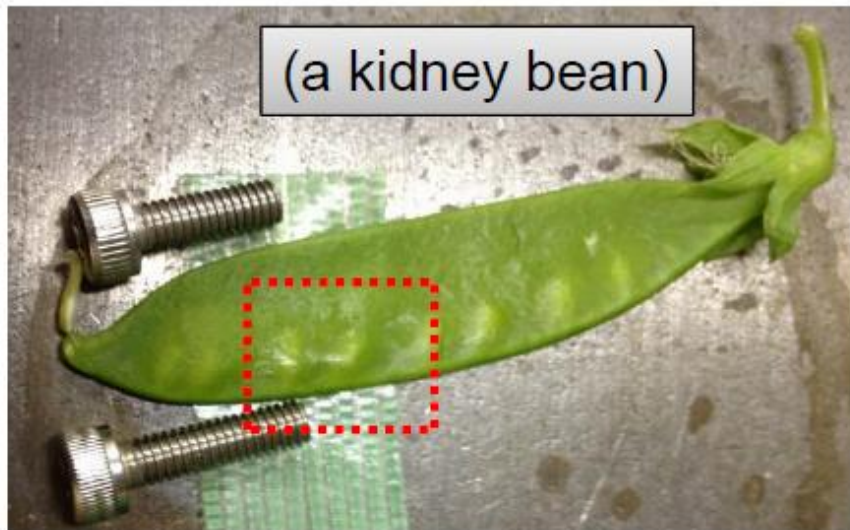
Silicon-On-Insulator Pixel Detector (SOIPIX)

SOI - Pixels

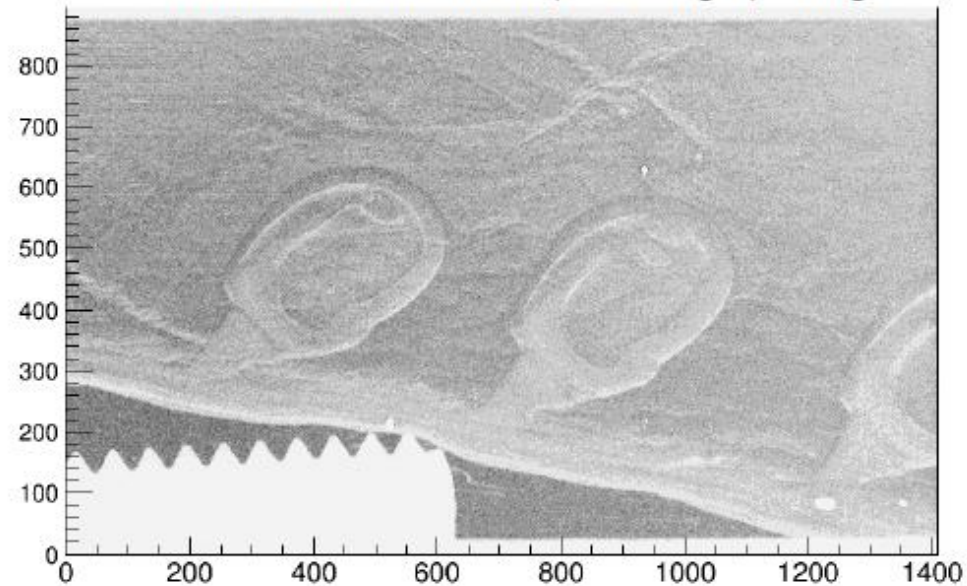


- + Dedicated sensor silicon + dedicated electronics silicon
- + Conceptually more radiation tolerance possible
- Thick BOX – Oxide may be vulnerable to radiation damage
- Still under early R&D, moderate industrial support

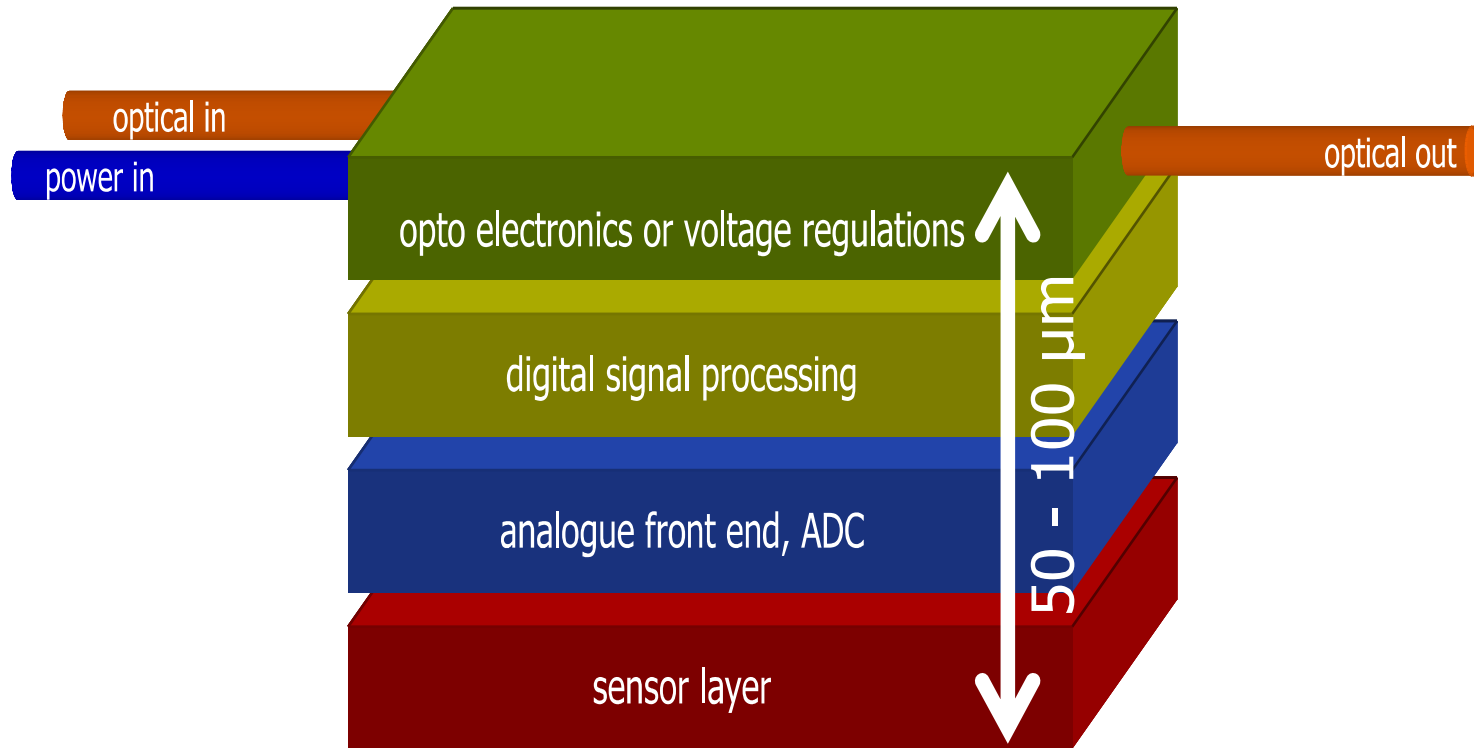
Latest news (Yasuo Arai, Vertex 2013)



Diffraction Enhanced (Low angle) Image

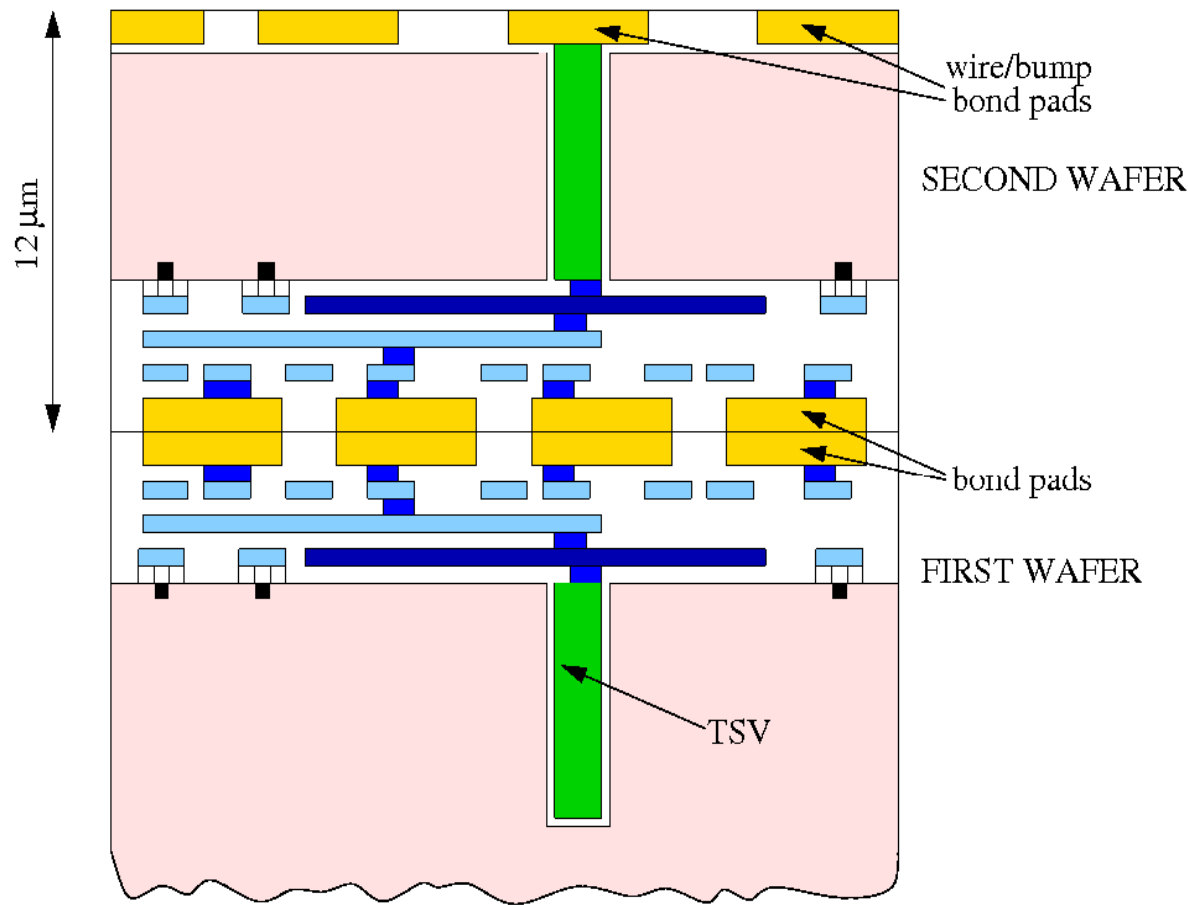


3D VLSI integration, the best of all worlds



- Individual chips form always a compromise.
- 3D VLSI integration aims to pile chips and to connect them
- Potential: Get the best of all worlds

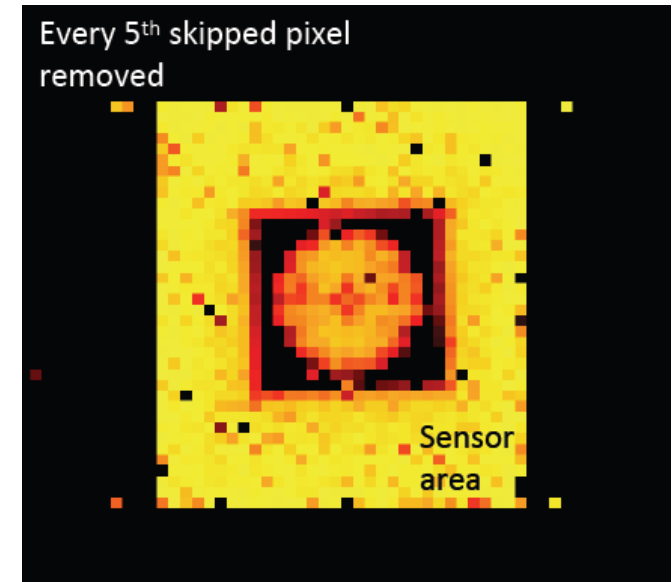
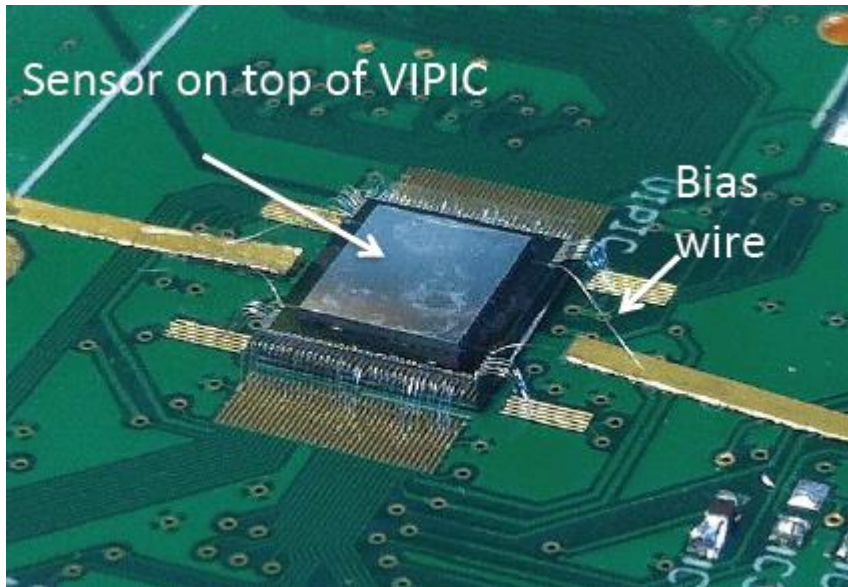
How to put chips together (simplified)



- Drill holes (via) deep into the chips and fill with metal
- Thin silicon until vias are seen on back side
- Add “bond pads” on the back side
- Bond chips

Status: (Ray Yarema, VERTEX2013)

- Prototypes submitted by large community, coordinated by Fermilab
- Industry failed with bonding => Years of delays and disasters
- Finally, few months ago:

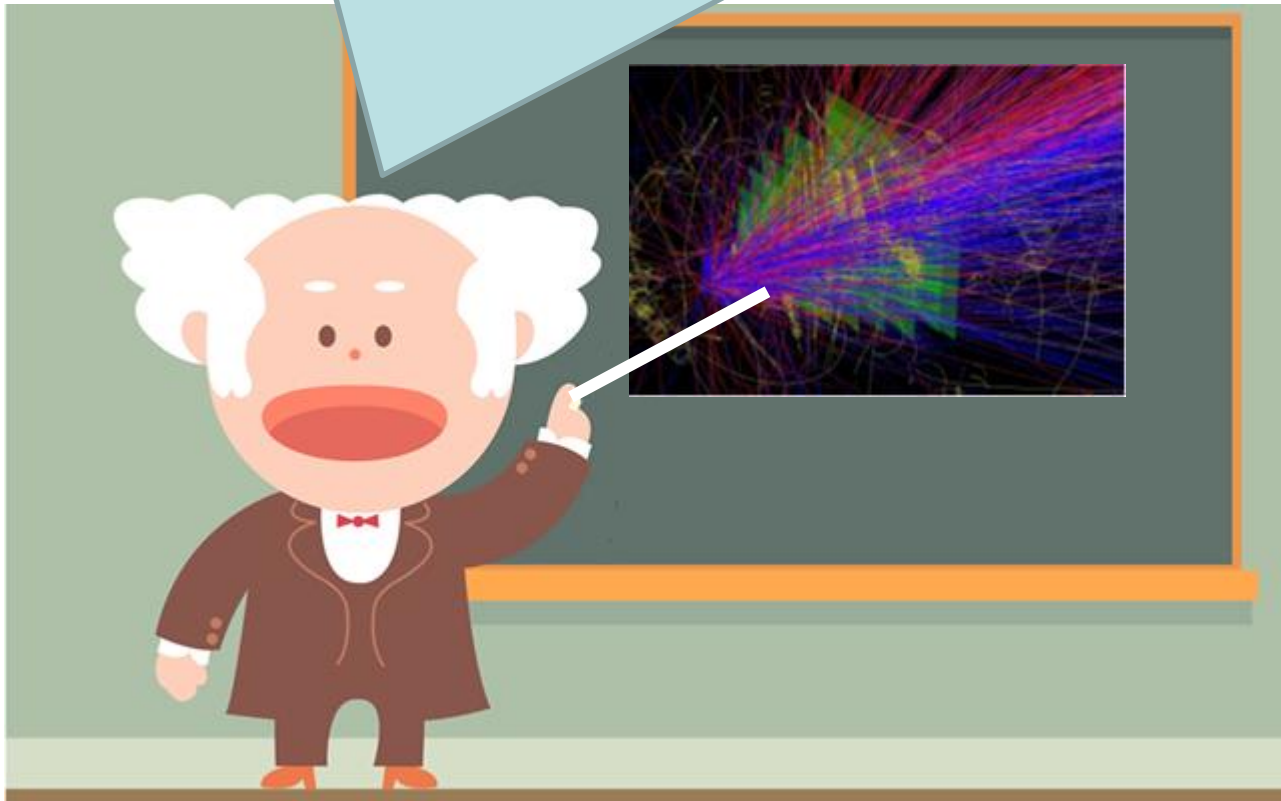
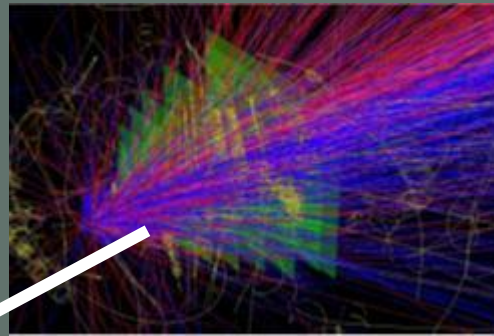


- First individual working devices delivered and tested
- Problems are understood:
 - a) Don't take industry by the letter
 - b) Use bigger "through vias" to ease alignment while bonding
- Future submissions should be much easier

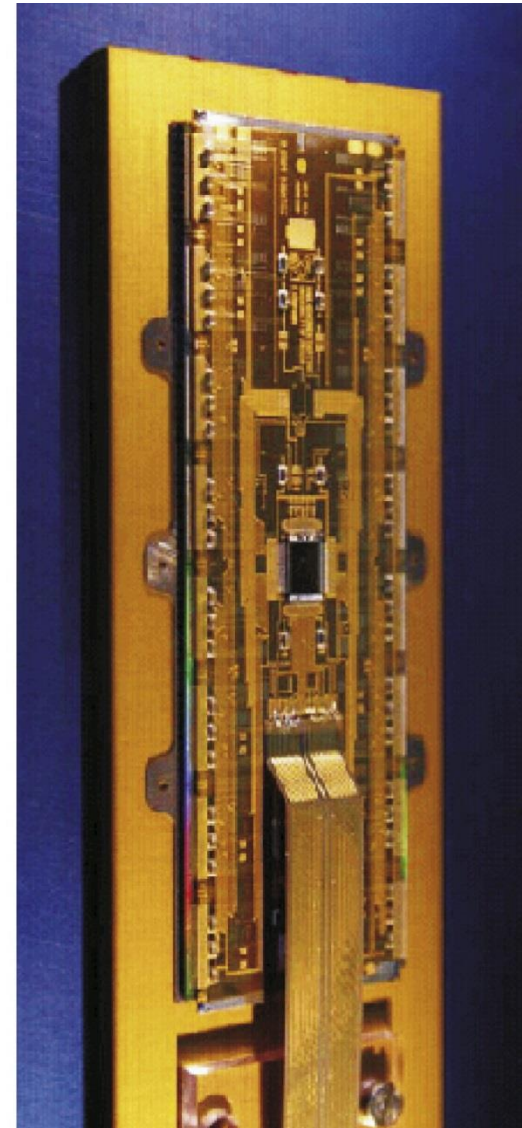
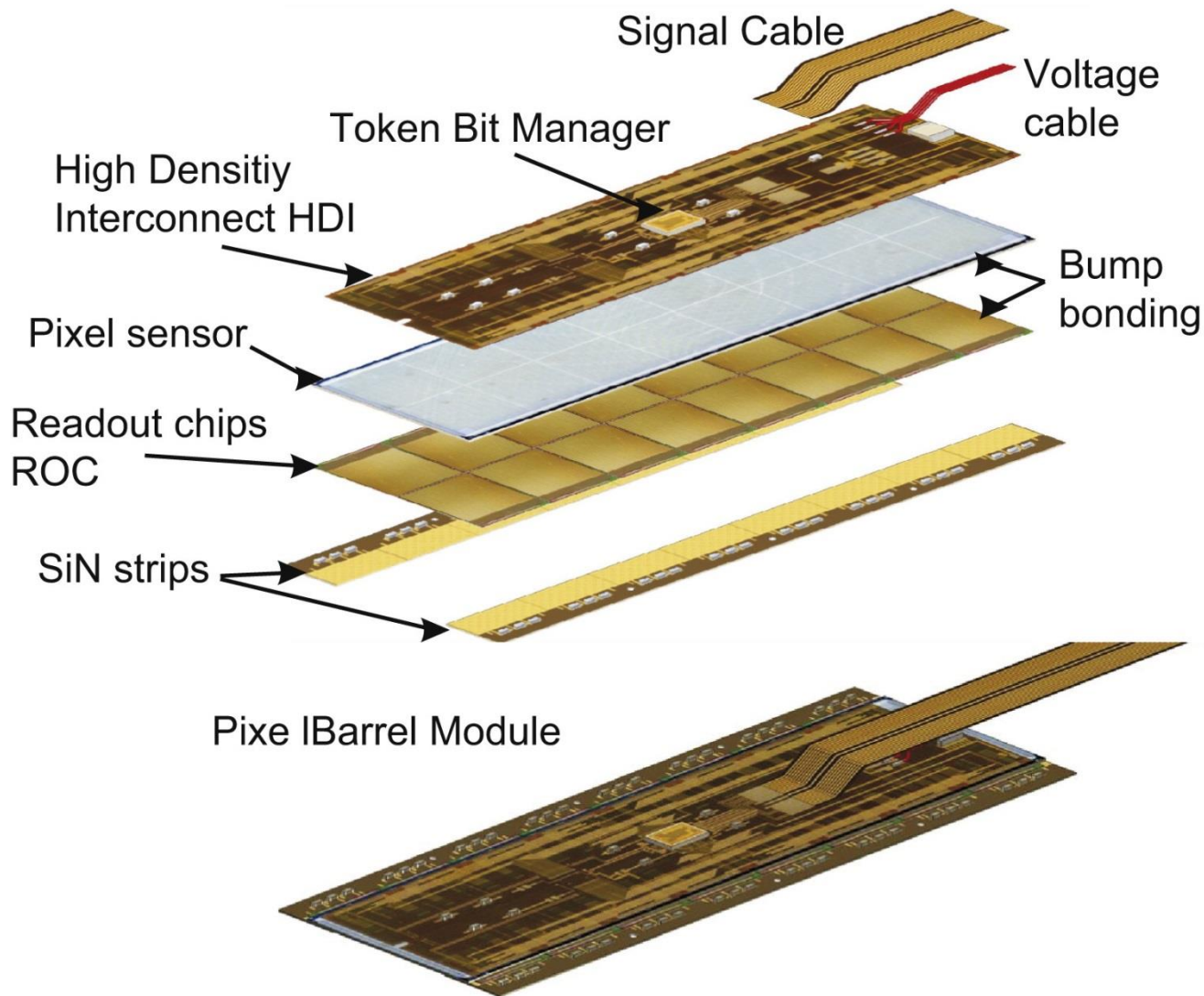
Ray Yarema: In hindsight, ... , we might have saved ~ 2 years and avoided a lot of grief. That's why it is called research.

The final question: How to do system integration

Again, this structure will be fixed with the novel ***Anti Gravitation Glue™***.

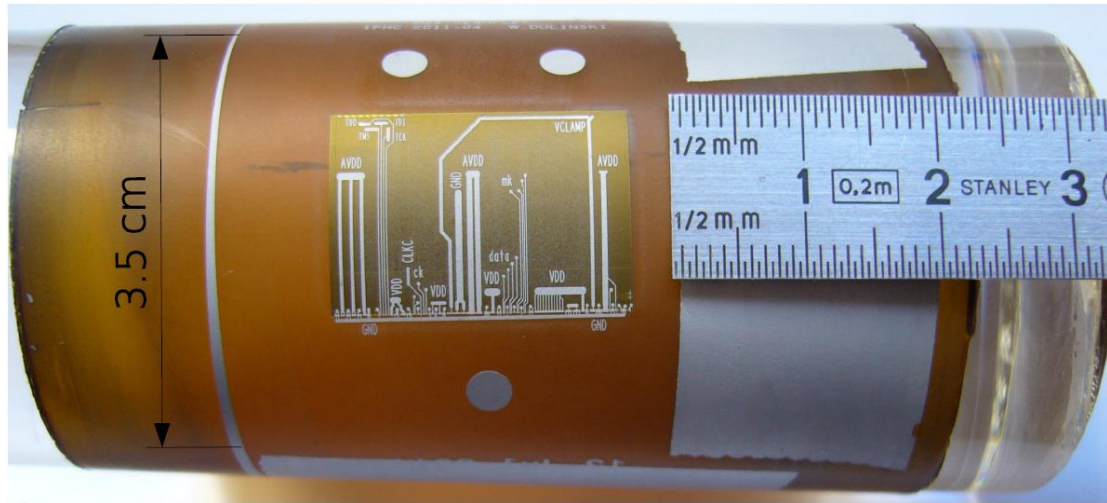


Outlook: The story has just started



Outlook: The story has just started

Idea from R. De Oliveira, W.Dulinski



SERNWIETE (mechanical demonstrator)
A bended MIMOSA-26 in a foil

My collaborators:



PICSEL group, IPHC Strasbourg

AG Prof. Stroth, Goethe University Frankfurt

What else should have been mentioned:

I. Peric, ZITI, Heidelberg – Partially depleted 2.5D MAPS

V. Re et al, INFN, Pavia, Bergamo – MAPS with discriminator/shaper

... and many others...